

Semiconducting Polymers

Field of the Invention

5 The invention relates to novel polymers containing repeating units based on thieno[3,4-b]thiophene, monomers and methods for their preparation, their use as semiconductors in organic electronic (OE) devices, especially in organic photovoltaic (OPV) devices, and to OE and OPV devices comprising these polymers.

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Background of the Invention

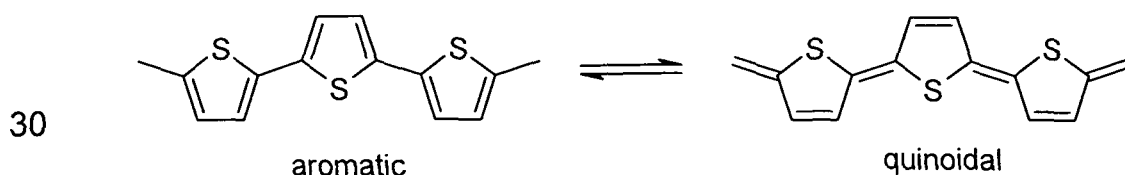
In recent years there has been growing interest in the use of semiconducting polymers for electronic applications. One particular area of importance is organic photovoltaics (OPV). Polymers have found use in OPVs as they allow devices to be manufactured by solution-processing techniques such as spin casting, dip coating or ink jet printing. Solution processing can be carried out cheaper and on a larger scale compared to the evaporative techniques used to make inorganic thin film devices.

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20 Currently, polymer based photovoltaic devices are achieving efficiencies up to 7%.

A class of polymers that is currently achieving the highest efficiencies in polymer based photovoltaic devices is based on units that have a high quinoidal contribution. Poly(thiophene), for example, can exist in both the aromatic and quinoidal state as shown below:

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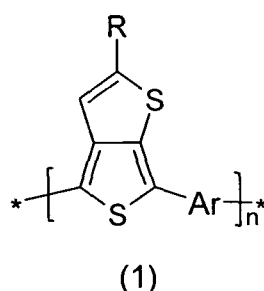


A quinoidal structure reduces the torsion between adjacent rings, which results in a more planar polymer backbone leading to an extension of the effective conjugation length. It is generally observed in conjugated polymers that an increase in the conjugation length results in a decrease

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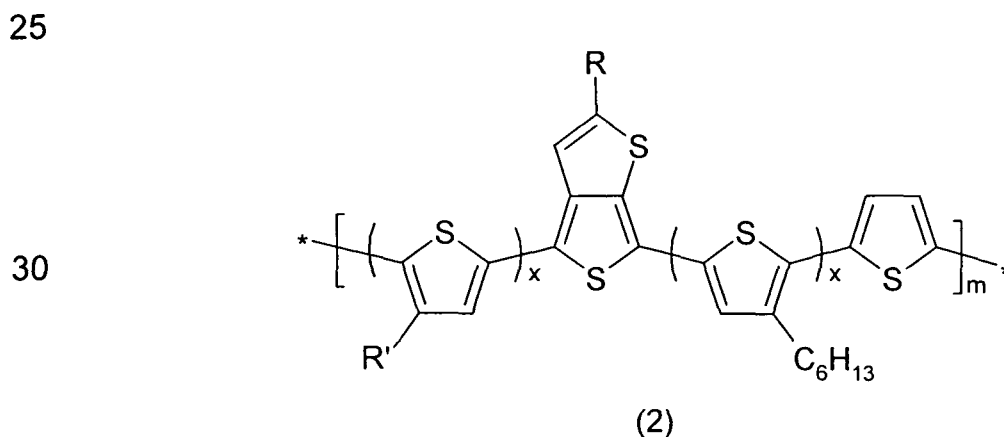
of the bandgap, leading to a higher degree of absorbed incident light.

The quinoidal state can be stabilised by fusing an aromatic ring to the thiophene backbone. The fused ring is itself only fully aromatic when the backbone is in the quinoidal state. This means there is a strong desire for the polymer to be in the quinoidal state. Previous work has demonstrated the use of a thieno[3,4-*b*]thiophene (1) [see Y. Liang; Y. Wu; D. Feng; S.-T. Tsai; H.-J. Son; G. Li; L. Yu, *J. Am. Chem. Soc.*, 2009, **131** (1), 56-57], as shown below (wherein R is an alkyl group and Ar is an aryl group), to reduce the bandgap.



However, the synthesis of polymer (1) involves an unstable monomer, namely a 4,6-dibromothieno[3,4-*b*]thiophene, which complicates the polymer synthesis by leading to unpredictable polymer molecular weights that lead to varying polymer performance.

WO 2010/008672 A1 discloses semiconducting conjugated polymers of formula (2) and their use in OPV devices.



wherein R is polyfluoroalkyl, polychloroalkyl or an ester, R' is alkyl, alkoxy, aryl, aryloxy, heteroaryl or heteroaryloxy, x is an integer from 1 to 12, and

m is an integer from 1 to 200.

5 However, these polymers have limited opportunities for fine-tuning of the HOMO and LUMO energy level positions. Furthermore, the positioning of the alkyl side chains limits the utilisation of phenylene ring based comonomers, as such configurations would result in significant steric hindrance due to outward positioning of alkyl substituents on the thiophene rings.

10 There is still a need for organic semiconducting (OSC) materials that are easy to synthesize, especially by methods suitable for mass production, show good structural organization and film-forming properties, exhibit good electronic properties, especially a high charge carrier mobility, good processibility, especially a high solubility in organic solvents, and high
15 stability in air. Especially for use in OPV cells, there is a need for OSC materials having a low bandgap, which enable improved light harvesting by the photoactive layer and can lead to higher cell efficiencies.

20 It was an aim of the present invention to provide compounds for use as organic semiconducting materials that do not have the drawbacks of prior art materials as described above, are easy to synthesize, especially by methods suitable for mass production, and do especially show good processibility, high stability, good solubility in organic solvents, high charge carrier mobility, and a low bandgap. Another aim of the invention was to
25 extend the pool of OSC materials available to the expert. Other aims of the present invention are immediately evident to the expert from the following detailed description.

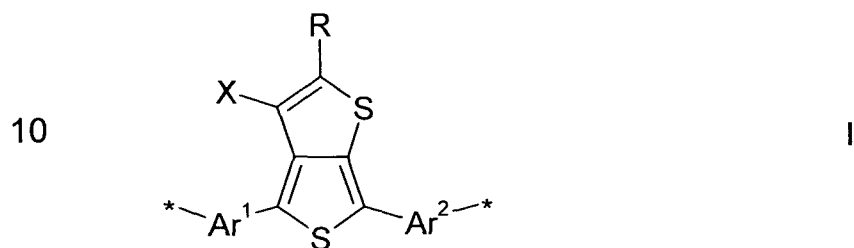
30 The inventors of the present invention have found that these aims can be achieved by providing conjugated semiconducting polymers as claimed in this application.

35 The monomers and polymers of the present invention are especially suitable for large scale production. At the same time, they show good processability, high solubility in organic solvents, low bandgap, high charge carrier mobility and high oxidative stability, and are promising

materials for organic electronic OE devices, especially for OPV devices.

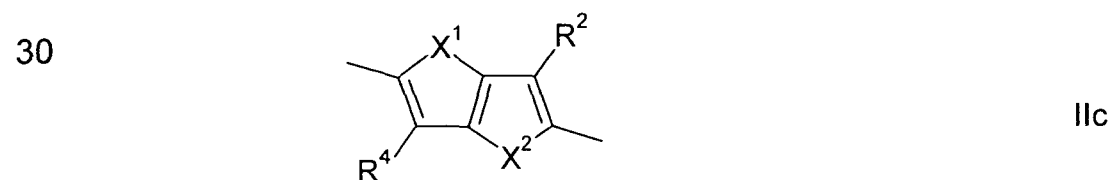
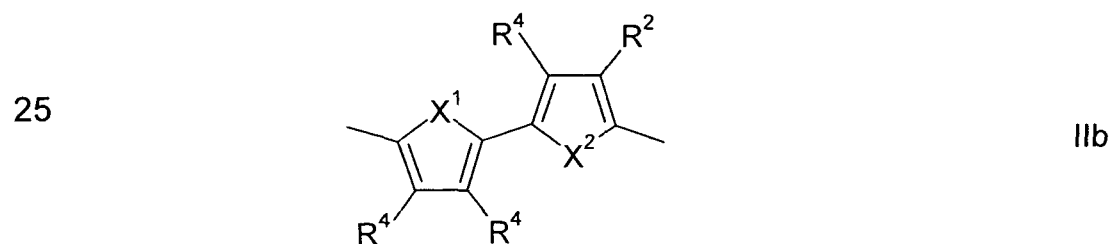
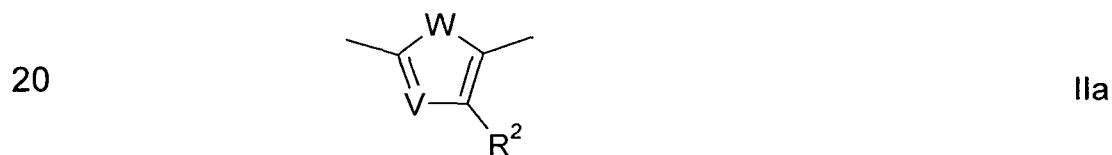
Summary of the Invention

- 5 The invention relates to a conjugated polymer comprising one or more identical or different repeating units of formula I:

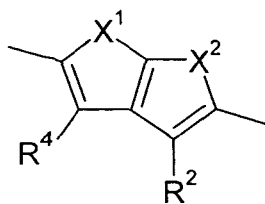


15 wherein the asterisks indicate a link to neighboured groups,

Ar¹ is on each occurrence identically or differently a group selected from the following formulae



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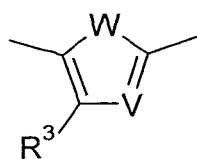


IId

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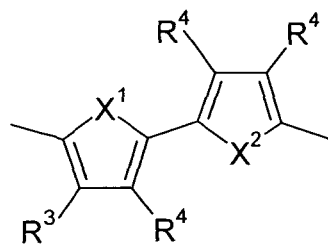
 Ar^2

is on each occurrence identically or differently a group selected from the following formulae



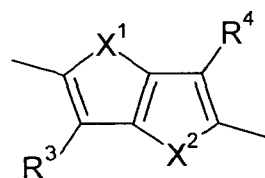
IIe

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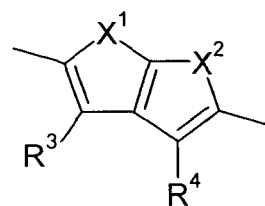
IIIf

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IIg

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IIh

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W

is S, Se or O,

V

is CH or N,

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 X^1 and X^2

are, on each occurrence identically or differently, and independently of each other, O, S or Se,

- X is H or F,
- 5 R on each occurrence identically or differently, denotes F, Cl, Br, I, CN, or straight-chain, branched or cyclic alkyl with 1 to 35 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -CO-, -CO-O-, -O-CO-, -O-CO-O-, -CR⁰=CR⁰⁰- or -C≡C- and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN, or
- 10 denotes aryl, heteroaryl, aryloxy, heteroaryloxy, arylcarbonyl, heteroarylcarbonyl, arylcarbonyloxy, heteroarylcarbonyloxy, aryloxy carbonyl or heteroaryloxy carbonyl having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R¹,
- 15 R⁰ and R⁰⁰ are independently of each other H or optionally substituted carbonyl or hydrocarbonyl optionally comprising one or more hetero atoms,
- 20 R¹ is on each occurrence identically or differently H, halogen, -CN, -NC, -NCO, -NCS, -OCN, -SCN, -C(=O)NR⁰R⁰⁰, -C(=O)X⁰, -C(=O)R⁰, -NH₂, -NR⁰R⁰⁰, -SH, -SR⁰, -SO₃H, -SO₂R⁰, -OH, -NO₂, -CF₃, -SF₅, optionally substituted silyl, carbonyl or hydrocarbonyl with 1 to 40 C atoms that is optionally substituted and optionally comprises one or more hetero
- 25 atoms, or P-Sp-,
- 30 R² and R³ on each occurrence identically or differently, and independently of each other, have one of the meanings given for R or R¹, which is preferably different from H,
- R⁴ has on each occurrence identically or differently one of the meanings given for R or R¹,
- 35 P is a polymerisable or crosslinkable group,
- Sp is a spacer group or a single bond,

X^0 is halogen.

5 The invention further relates to a conjugated polymer comprising identical or different repeating units, wherein at least one repeating unit contains a unit of formula I, and optionally comprising one or more units Ar selected from aryl and heteroaryl units that are optionally substituted.

10 Preferably these polymers are selected of formula III:



wherein

15 U is, on each occurrence identically or differently, a unit of formula I as described above and below,

Ar is, on each occurrence identically or differently, an aryl or heteroaryl group that is optionally substituted,

20 x is on each occurrence identically or differently 0, 1 or 2, wherein in at least one repeating unit, i.e. in at least one unit $-(U)_x-(Ar)_y-$, x is 1,

25 y is on each occurrence identically or differently 0, 1 or 2,

n is an integer > 1.

30 The invention further relates to monomers containing a unit of formula I, which are suitable for the preparation of polymers as described above and below.

35 The invention further relates to a mixture or blend comprising one or more polymers according to the present invention and one or more additional compounds or polymers which are preferably selected from compounds and polymers having semiconducting, charge transport, hole/electron

transport, hole/electron blocking, electrically conducting, photoconducting or light emitting properties.

5 The invention further relates to a formulation comprising one or more polymers, mixtures or or blends according to the present invention and optionally one or more solvents, preferably selected from organic solvents.

10 The invention further relates to the use of polymers, mixtures, blends and formulations according to the present invention as charge transport, semiconducting, electrically conducting, photoconducting or light emitting material in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices.

15 The invention further relates to a charge transport, semiconducting, electrically conducting, photoconducting or light emitting material or component comprising one or more polymers, polymer blends of formulations according to the present invention.

20 The invention further relates to an optical, electrooptical or electronic component or device comprising one or more polymers, polymer blends, formulations, components or materials according to the present invention.

25 The optical, electrooptical, electronic electroluminescent and photoluminescent components or devices include, without limitation, organic field effect transistors (OFET), thin film transistors (TFT), integrated circuits (IC), logic circuits, capacitors, radio frequency identification (RFID) tags, devices or components, organic light emitting diodes (OLED), organic light emitting transistors (OLET), flat panel displays, backlights of displays, organic photovoltaic devices (OPV), solar
30 cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, sensor devices, charge injection layers, charge transport layers or interlayers in polymer light emitting diodes (PLEDs), organic plasmon-emitting diodes (OPEDs), Schottky diodes, planarising layers, antistatic
35 films, polymer electrolyte membranes (PEM), conducting substrates, conducting patterns, electrode materials in batteries, alignment layers,

biosensors, biochips, security markings, security devices, and components or devices for detecting and discriminating DNA sequences.

Detailed Description of the Invention

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The monomers and polymers of the present invention are easy to synthesize and exhibit several advantageous properties, like a low bandgap, a high charge carrier mobility, a high solubility in organic solvents, a good processability for the device manufacture process, a high
10 oxidative stability and a long lifetime in electronic devices.

In addition, they show the following advantageous properties:

i) The 4,6-bis(5-bromo-thiophen-2-yl)-thieno[3,4-b]thiophene monomers
15 exhibit better thermal, light and air stability compare to the 4,6-dibromo-thieno[3,4-b]thiophene monomer counterpart.

ii) The two additional thiophene rings on both sides of the thieno[3,4-b]thiophene group extend the conjugation length, thereby lowering the
20 band gap of the resultant polymer and improving the light harvesting ability of the material.

iii) Additional solubility can be introduced into the polymer by inclusion of solubilising groups at the R, R² or R³ positions.

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iv) Additional fine-tuning of the electronic energies (HOMO/LUMO levels) by *either* careful selection of thiophene R² and R³ group on each side of 4,6-di-thiophen-2-yl-thieno[3,4-b]thiophene *or* co-polymerisation with appropriate co-monomer(s) should afford candidate materials for organic
30 photovoltaic applications.

v) The increase in monomer stability results in better reproducibility of the polymer molecular weights obtained, and therefore in better reproducibility of the polymer performance, compared to polymers as described in prior
35 art, like e.g. in WO 2010/008672 A.

The term "polymer" generally means a molecule of high relative molecular mass, the structure of which essentially comprises the multiple repetition of units derived, actually or conceptually, from molecules of low relative molecular mass (PAC, 1996, 68, 2291). The term "oligomer" generally means a molecule of intermediate relative molecular mass, the structure of which essentially comprises a small plurality of units derived, actually or conceptually, from molecules of lower relative molecular mass (PAC, 1996, 68, 2291). In a preferred sense according to the present invention a polymer means a compound having > 1 , preferably ≥ 5 repeating units, and an oligomer means a compound with > 1 and < 10 , preferably < 5 , repeating units.

Above and below, in a formula showing a polymer or a repeating unit, like formula I and its subformulae, an asterisk ("*") denotes a linkage to an adjacent repeating unit or a terminal group in the polymer chain.

The terms "repeating unit" and "monomeric unit" mean the constitutional repeating unit (CRU), which is the smallest constitutional unit the repetition of which constitutes a regular macromolecule, a regular oligomer molecule, a regular block or a regular chain (PAC, 1996, 68, 2291).

The term "leaving group" means an atom or group (charged or uncharged) that becomes detached from an atom in what is considered to be the residual or main part of the molecule taking part in a specified reaction (see also PAC, 1994, 66, 1134).

The term "conjugated" means a compound containing mainly C atoms with sp^2 -hybridisation (or optionally also sp -hybridisation), which may also be replaced by hetero atoms. In the simplest case this is for example a compound with alternating C-C single and double (or triple) bonds, but does also include compounds with units like 1,3-phenylene. "Mainly" means in this connection that a compound with naturally (spontaneously) occurring defects, which may lead to interruption of the conjugation, is still regarded as a conjugated compound.

Unless stated otherwise, the molecular weight is given as the number average molecular weight M_n or weight average molecular weight M_w , which is determined by gel permeation chromatography (GPC) against polystyrene standards in eluent solvents such as tetrahydrofuran, trichloromethane (TCM, chloroform), chlorobenzene or 1, 2, 4-trichlorobenzene. Unless stated otherwise, trichloromethane is used as solvent. The degree of polymerization (n) means the number average degree of polymerization given as $n = M_n/M_U$, wherein M_U is the molecular weight of the single repeating unit as described in J. M. G. Cowie, *Polymers: Chemistry & Physics of Modern Materials*, Blackie, Glasgow, 1991.

The term "carbyl group" as used above and below denotes any monovalent or multivalent organic radical moiety which comprises at least one carbon atom either without any non-carbon atoms (like for example $-C\equiv C-$), or optionally combined with at least one non-carbon atom such as N, O, S, P, Si, Se, As, Te or Ge (for example carbonyl etc.). The term "hydrocarbyl group" denotes a carbyl group that does additionally contain one or more H atoms and optionally contains one or more hetero atoms like for example N, O, S, P, Si, Se, As, Te or Ge.

A carbyl or hydrocarbyl group comprising a chain of 3 or more C atoms may also be straight-chain, branched and/or cyclic, including spiro and/or fused rings.

Preferred carbyl and hydrocarbyl groups include alkyl, alkoxy, alkylcarbonyl, alkoxycarbonyl, alkylcarbonyloxy and alkoxycarbonyloxy, each of which is optionally substituted and has 1 to 40, preferably 1 to 25, very preferably 1 to 18 C atoms, furthermore optionally substituted aryl or aryloxy having 6 to 40, preferably 6 to 25 C atoms, furthermore alkylaryloxy, arylcarbonyl, aryloxy carbonyl, arylcarbonyloxy and aryloxy carbonyloxy, each of which is optionally substituted and has 6 to 40, preferably 7 to 40 C atoms, wherein all these groups do optionally contain one or more hetero atoms, preferably selected from N, O, S, P, Si, Se, As, Te and Ge.

The carbyl or hydrocarbyl group may be a saturated or unsaturated acyclic

group, or a saturated or unsaturated cyclic group. Unsaturated acyclic or cyclic groups are preferred, especially aryl, alkenyl and alkynyl groups (especially ethynyl). Where the C₁-C₄₀ carbyl or hydrocarbyl group is acyclic, the group may be straight-chain or branched. The C₁-C₄₀ carbyl or hydrocarbyl group includes for example: a C₁-C₄₀ alkyl group, a C₁-C₄₀ alkoxy or oxaalkyl group, a C₂-C₄₀ alkenyl group, a C₂-C₄₀ alkynyl group, a C₃-C₄₀ allyl group, a C₄-C₄₀ alkyldienyl group, a C₄-C₄₀ polyenyl group, a C₆-C₁₈ aryl group, a C₆-C₄₀ alkylaryl group, a C₆-C₄₀ arylalkyl group, a C₄-C₄₀ cycloalkyl group, a C₄-C₄₀ cycloalkenyl group, and the like. Preferred among the foregoing groups are a C₁-C₂₀ alkyl group, a C₂-C₂₀ alkenyl group, a C₂-C₂₀ alkynyl group, a C₃-C₂₀ allyl group, a C₄-C₂₀ alkyldienyl group, a C₆-C₁₂ aryl group and a C₄-C₂₀ polyenyl group, respectively. Also included are combinations of groups having carbon atoms and groups having hetero atoms, like e.g. an alkynyl group, preferably ethynyl, that is substituted with a silyl group, preferably a trialkylsilyl group.

Aryl and heteroaryl preferably denote a mono-, bi- or tricyclic aromatic or heteroaromatic group with 4 to 30 ring atoms that may also comprise condensed rings and is optionally substituted with one or more groups L as defined above.

Very preferred substituents L are selected from halogen, most preferably F, or alkyl, alkoxy, oxaalkyl, thioalkyl, fluoroalkyl and fluoroalkoxy with 1 to 12 C atoms or alkenyl, alkynyl with 2 to 12 C atoms.

Especially preferred aryl and heteroaryl groups are phenyl in which, in addition, one or more CH groups may be replaced by N, naphthalene, thiophene, selenophene, thienothiophene, dithienothiophene, fluorene and oxazole, all of which can be unsubstituted, mono- or polysubstituted with L as defined above. Very preferred rings are selected from pyrrole, preferably N-pyrrole, pyridine, preferably 2- or 3-pyridine, pyrimidine, thiophene preferably 2-thiophene, selenophene, preferably 2-selenophene, thieno[3,2-b]thiophene, thiazole, thiadiazole, oxazole and oxadiazole, especially preferably thiophene-2-yl, 5-substituted thiophene-2-yl or pyridine-3-yl, all of which can be unsubstituted, mono- or polysubstituted with L as defined above.

An alkyl or alkoxy radical, i.e. where the terminal CH₂ group is replaced by -O-, can be straight-chain or branched. It is preferably straight-chain, has 2, 3, 4, 5, 6, 7 or 8 carbon atoms and accordingly is preferably ethyl, propyl, butyl, pentyl, hexyl, heptyl, octyl, ethoxy, propoxy, butoxy, pentoxy, hexoxy, heptoxy, or octoxy, furthermore methyl, nonyl, decyl, undecyl, dodecyl, tridecyl, tetradecyl, pentadecyl, nonoxy, decoxy, undecoxy, dodecoxy, tridecoxy or tetradecoxy, for example.

An alkenyl group, wherein one or more CH₂ groups are replaced by -CH=CH- can be straight-chain or branched. It is preferably straight-chain, has 2 to 10 C atoms and accordingly is preferably vinyl, prop-1-, or prop-2-enyl, but-1-, 2- or but-3-enyl, pent-1-, 2-, 3- or pent-4-enyl, hex-1-, 2-, 3-, 4- or hex-5-enyl, hept-1-, 2-, 3-, 4-, 5- or hept-6-enyl, oct-1-, 2-, 3-, 4-, 5-, 6- or oct-7-enyl, non-1-, 2-, 3-, 4-, 5-, 6-, 7- or non-8-enyl, dec-1-, 2-, 3-, 4-, 5-, 6-, 7-, 8- or dec-9-enyl.

Especially preferred alkenyl groups are C₂-C₇-1E-alkenyl, C₄-C₇-3E-alkenyl, C₅-C₇-4-alkenyl, C₆-C₇-5-alkenyl and C₇-6-alkenyl, in particular C₂-C₇-1E-alkenyl, C₄-C₇-3E-alkenyl and C₅-C₇-4-alkenyl. Examples for particularly preferred alkenyl groups are vinyl, 1E-propenyl, 1E-butenyl, 1E-pentenyl, 1E-hexenyl, 1E-heptenyl, 3-butenyl, 3E-pentenyl, 3E-hexenyl, 3E-heptenyl, 4-pentenyl, 4Z-hexenyl, 4E-hexenyl, 4Z-heptenyl, 5-hexenyl, 6-heptenyl and the like. Groups having up to 5 C atoms are generally preferred.

An oxaalkyl group, i.e. where one CH₂ group is replaced by -O-, is preferably straight-chain 2-oxapropyl (=methoxymethyl), 2-(=ethoxymethyl) or 3-oxabutyl (=2-methoxyethyl), 2-, 3-, or 4-oxapentyl, 2-, 3-, 4-, or 5-oxahexyl, 2-, 3-, 4-, 5-, or 6-oxaheptyl, 2-, 3-, 4-, 5-, 6- or 7-oxaoctyl, 2-, 3-, 4-, 5-, 6-, 7- or 8-oxanonyl or 2-, 3-, 4-, 5-, 6-, 7-, 8- or 9-oxadecyl, for example. Oxaalkyl, i.e. where one CH₂ group is replaced by -O-, is preferably straight-chain 2-oxapropyl (=methoxymethyl), 2-(=ethoxymethyl) or 3-oxabutyl (=2-methoxyethyl), 2-, 3-, or 4-oxapentyl, 2-, 3-, 4-, or 5-oxahexyl, 2-, 3-, 4-, 5-, or 6-oxaheptyl, 2-, 3-, 4-, 5-, 6- or 7-

oxaoctyl, 2-, 3-, 4-, 5-, 6-, 7- or 8-oxanonyl or 2-, 3-, 4-, 5-, 6-, 7-, 8- or 9-oxadecyl, for example.

5 In an alkyl group wherein one CH₂ group is replaced by -O- and one by -CO-, these radicals are preferably neighboured. Accordingly these radicals together form a carbonyloxy group -CO-O- or an oxycarbonyl group -O-CO-. Preferably this group is straight-chain and has 2 to 6 C atoms. It is accordingly preferably acetyloxy, propionyloxy, butyryloxy, pentanoyloxy, hexanoyloxy, acetyloxymethyl, propionyloxymethyl, 10 butyryloxymethyl, pentanoyloxymethyl, 2-acetyloxyethyl, 2-propionyloxyethyl, 2-butyryloxyethyl, 3-acetyloxypropyl, 3-propionyloxypropyl, 4-acetyloxybutyl, methoxycarbonyl, ethoxycarbonyl, propoxycarbonyl, butoxycarbonyl, pentoxycarbonyl, methoxycarbonylmethyl, ethoxycarbonylmethyl, propoxycarbonylmethyl, butoxycarbonylmethyl, 15 2-(methoxycarbonyl)ethyl, 2-(ethoxycarbonyl)ethyl, 2-(propoxycarbonyl)ethyl, 3-(methoxycarbonyl)propyl, 3-(ethoxycarbonyl)propyl, 4-(methoxycarbonyl)-butyl.

20 An alkyl group wherein two or more CH₂ groups are replaced by -O- and/or -COO- can be straight-chain or branched. It is preferably straight-chain and has 3 to 12 C atoms. Accordingly it is preferably bis-carboxymethyl, 2,2-bis-carboxy-ethyl, 3,3-bis-carboxy-propyl, 4,4-bis-carboxy-butyl, 5,5-bis-carboxy-pentyl, 6,6-bis-carboxy-hexyl, 7,7-bis-carboxy-heptyl, 8,8-bis-carboxy-octyl, 9,9-bis-carboxy-nonyl, 10,10-bis-carboxy-decyl, bis-(methoxycarbonyl)-methyl, 2,2-bis-(methoxycarbonyl)-ethyl, 25 3,3-bis-(methoxycarbonyl)-propyl, 4,4-bis-(methoxycarbonyl)-butyl, 5,5-bis-(methoxycarbonyl)-pentyl, 6,6-bis-(methoxycarbonyl)-hexyl, 7,7-bis-(methoxycarbonyl)-heptyl, 8,8-bis-(methoxycarbonyl)-octyl, bis-(ethoxycarbonyl)-methyl, 2,2-bis-(ethoxycarbonyl)-ethyl, 3,3-bis-(ethoxycarbonyl)-propyl, 4,4-bis-(ethoxycarbonyl)-butyl, 5,5-bis-(ethoxycarbonyl)-hexyl. 30

A thioalkyl group, i.e where one CH₂ group is replaced by -S-, is preferably straight-chain thiomethyl (-SCH₃), 1-thioethyl (-SCH₂CH₃), 1-thiopropyl (= -SCH₂CH₂CH₃), 1- (thiobutyl), 1-(thiopentyl), 1-(thiohexyl), 1-(thioheptyl), 1-(thiooctyl), 1-(thiononyl), 1-(thiodecyl), 1-(thioundecyl) or 1-

(thiododecyl), wherein preferably the CH₂ group adjacent to the sp² hybridised vinyl carbon atom is replaced.

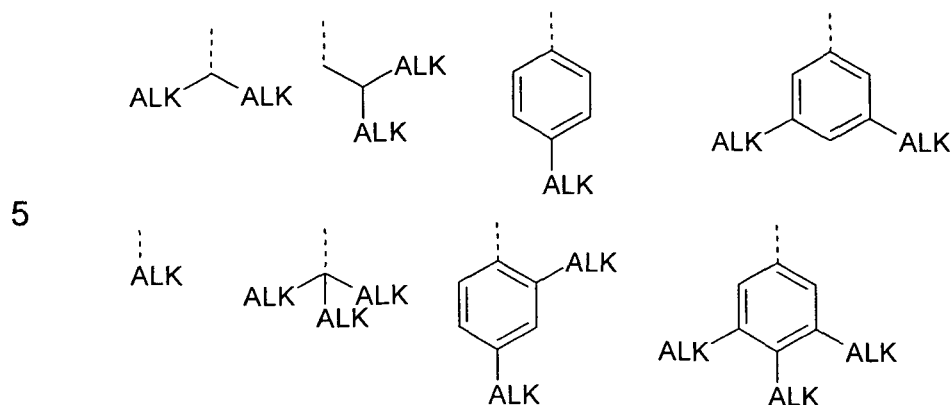
5 A fluoroalkyl group is preferably straight-chain perfluoroalkyl C_iF_{2i+1}, wherein i is an integer from 1 to 15, in particular CF₃, C₂F₅, C₃F₇, C₄F₉, C₅F₁₁, C₆F₁₃, C₇F₁₅ or C₈F₁₇, very preferably C₆F₁₃.

10 The above-mentioned alkyl, alkoxy, alkenyl, oxaalkyl, thioalkyl, carbonyl and carbonyloxy groups can be achiral or chiral groups. Particularly preferred chiral groups are 2-butyl (=1-methylpropyl), 2-methylbutyl, 2-methylpentyl, 3-methylpentyl, 2-ethylhexyl, 2-propylpentyl, in particular 2-methylbutyl, 2-methylbutoxy, 2-methylpentoxy, 3-methylpentoxy, 2-ethylhexoxy, 1-methylhexoxy, 2-octyloxy, 2-oxa-3-methylbutyl, 3-oxa-4-methylpentyl, 4-methylhexyl, 2-hexyl, 2-octyl, 2-nonyl, 2-decyl, 2-dodecyl, 6-methoxyoctoxy, 6-methyloctoxy, 6-methyloctanoyloxy, 5-methylheptyloxy-carbonyl, 2-methylbutyryloxy, 3-methylvaleryloxy, 4-methylhexanoyloxy, 2-chloropropionyloxy, 2-chloro-3-methylbutyryloxy, 2-chloro-4-methylvaleryl-oxy, 2-chloro-3-methylvaleryloxy, 2-methyl-3-oxapentyl, 2-methyl-3-oxa-hexyl, 1-methoxypropyl-2-oxy, 1-ethoxypropyl-2-oxy, 1-propoxypropyl-2-oxy, 20 1-butoxypropyl-2-oxy, 2-fluorooctyloxy, 2-fluorodecyloxy, 1,1,1-trifluoro-2-octyloxy, 1,1,1-trifluoro-2-octyl, 2-fluoromethyloctyloxy for example. Very preferred are 2-hexyl, 2-octyl, 2-octyloxy, 1,1,1-trifluoro-2-hexyl, 1,1,1-trifluoro-2-octyl and 1,1,1-trifluoro-2-octyloxy.

25 Preferred achiral branched groups are isopropyl, isobutyl (=methylpropyl), isopentyl (=3-methylbutyl), tert. butyl, isopropoxy, 2-methyl-propoxy and 3-methylbutoxy.

30 In another preferred embodiment of the present invention, R, R² or R³ are selected from primary, secondary or tertiary alkyl or alkoxy with 1 to 30 C atoms, wherein one or more H atoms are optionally replaced by F, or aryl, aryloxy, heteroaryl or heteroaryloxy that is optionally alkylated or alkoxyated and has 4 to 30 ring atoms. Very preferred groups of this type are selected from the group consisting of the following formulae

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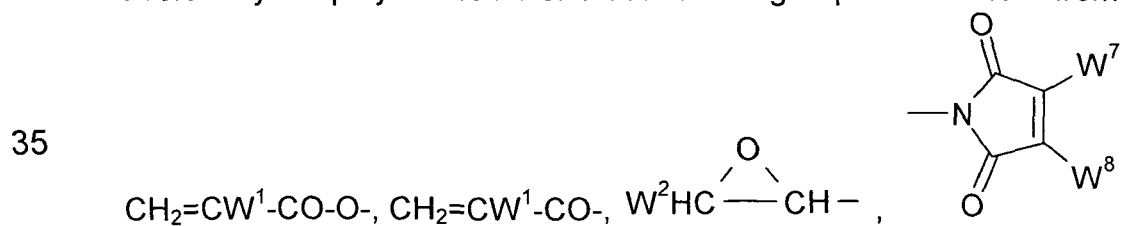
wherein "ALK" denotes optionally fluorinated, preferably linear, alkyl or alkoxy with 1 to 20, preferably 1 to 12 C-atoms, in case of tertiary groups very preferably 1 to 9 C atoms, and the dashed line denotes a link to the ring to which these groups are attached. Especially preferred among these groups are those wherein all ALK subgroups are identical.

-CY¹=CY²- is preferably -CH=CH-, -CF=CF- or -CH=C(CN)-.

Halogen is F, Cl, Br or I, preferably F, Cl or Br.

The polymers may also be substituted with a polymerisable or crosslinkable reactive group, which is optionally protected during the process of forming the polymer. Particular preferred polymers of this type are those of formula I wherein R¹ denotes P-Sp. These polymers are particularly useful as semiconductors or charge transport materials, as they can be crosslinked via the groups P, for example by polymerisation in situ, during or after processing the polymer into a thin film for a semiconductor component, to yield crosslinked polymer films with high charge carrier mobility and high thermal, mechanical and chemical stability.

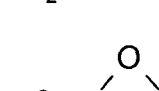
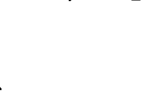
Preferably the polymerisable or crosslinkable group P is selected from




 W^2  $(CH_2)_{k_1}-O-$, $CH_2=CW^2-(O)_{k_1}-$, $CW^1=CH-CO-(O)_{k_3}-$, $CW^1=CH-$
 $CO-NH-$, $CH_2=CW^1-CO-NH-$, $CH_3-CH=CH-O-$, $(CH_2=CH)_2CH-OCO-$,
5 $(CH_2=CH-CH_2)_2CH-O-CO-$, $(CH_2=CH)_2CH-O-$, $(CH_2=CH-CH_2)_2N-$,
 $(CH_2=CH-CH_2)_2N-CO-$, $HO-CW^2W^3-$, $HS-CW^2W^3-$, HW^2N- , $HO-CW^2W^3-$
 $NH-$, $CH_2=CH-(CO-O)_{k_1}-Phe-(O)_{k_2}-$, $CH_2=CH-(CO)_{k_1}-Phe-(O)_{k_2}-$, $Phe-$
 $CH=CH-$, $HOOC-$, $OCN-$, and $W^4W^5W^6Si-$, with W^1 being H, F, Cl, CN,
 CF_3 , phenyl or alkyl with 1 to 5 C-atoms, in particular H, Cl or CH_3 , W^2 and
10 W^3 being independently of each other H or alkyl with 1 to 5 C-atoms, in
particular H, methyl, ethyl or n-propyl, W^4 , W^5 and W^6 being independently
of each other Cl, oxaalkyl or oxacarbonylalkyl with 1 to 5 C-atoms, W^7 and
 W^8 being independently of each other H, Cl or alkyl with 1 to 5 C-atoms,
15 Phe being 1,4-phenylene that is optionally substituted by one or more
groups L as defined above, k_1 , k_2 and k_3 being independently of each
other 0 or 1, k_3 preferably being 1, and k_4 being an integer from 1 to 10.

20 Alternatively P is a protected derivative of these groups which is non-
reactive under the conditions described for the process according to the
present invention. Suitable protective groups are known to the ordinary
expert and described in the literature, for example in Green, "Protective
Groups in Organic Synthesis", John Wiley and Sons, New York (1981),
like for example acetals or ketals.

25 Especially preferred groups P are $CH_2=CH-CO-O-$, $CH_2=C(CH_3)-CO-O-$,
 $CH_2=CF-CO-O-$, $CH_2=CH-O-$, $(CH_2=CH)_2CH-O-CO-$, $(CH_2=CH)_2CH-O-$,


 W^2HC  $CH-$ and W^2  $(CH_2)_{k_1}-O-$, or protected derivatives
30 thereof. Further preferred groups P are selected from the group consisting
of vinyloxy, acrylate, methacrylate, fluoroacrylate, chloracrylate, oxetan
and epoxy groups, very preferably from an acrylate or methacrylate group.

35 Polymerisation of group P can be carried out according to methods that are
known to the ordinary expert and described in the literature, for example in
D. J. Broer; G. Challa; G. N. Mol, *Macromol. Chem*, 1991, **192**, 59.

The term "spacer group" is known in prior art and suitable spacer groups Sp are known to the ordinary expert (see e.g. Pure Appl. Chem. 73(5), 888 (2001)). The spacer group Sp is preferably of formula Sp'-X', such that P-Sp- is P-Sp'-X'-, wherein

5

Sp' is alkylene with up to 30 C atoms which is unsubstituted or mono- or polysubstituted by F, Cl, Br, I or CN, it being also possible for one or more non-adjacent CH₂ groups to be replaced, in each case independently from one another, by -

10

O-, -S-, -NH-, -NR⁰-, -SiR⁰R⁰⁰-, -CO-, -COO-, -OCO-, -OCO-O-, -S-CO-, -CO-S-, -CH=CH- or -C≡C- in such a manner that O and/or S atoms are not linked directly to one another,

15

X' is -O-, -S-, -CO-, -COO-, -OCO-, -O-COO-, -CO-NR⁰-, -NR⁰-CO-, -NR⁰-CO-NR⁰⁰-, -OCH₂-, -CH₂O-, -SCH₂-, -CH₂S-, -CF₂O-, -OCF₂-, -CF₂S-, -SCF₂-, -CF₂CH₂-, -CH₂CF₂-, -CF₂CF₂-, -CH=N-, -N=CH-, -N=N-, -CH=CR⁰-, -CY¹=CY²-, -C≡C-, -CH=CH-COO-, -OCO-CH=CH- or a single bond,

20

R⁰ and R⁰⁰ are independently of each other H or alkyl with 1 to 12 C-atoms, and

Y¹ and Y² are independently of each other H, F, Cl or CN.

25

X' is preferably -O-, -S-, -OCH₂-, -CH₂O-, -SCH₂-, -CH₂S-, -CF₂O-, -OCF₂-, -CF₂S-, -SCF₂-, -CH₂CH₂-, -CF₂CH₂-, -CH₂CF₂-, -CF₂CF₂-, -CH=N-, -N=CH-, -N=N-, -CH=CR⁰-, -CY¹=CY²-, -C≡C- or a single bond, in particular -O-, -S-, -C≡C-, -CY¹=CY²- or a single bond. In another preferred embodiment X' is a group that is able to form a conjugated system, such

30

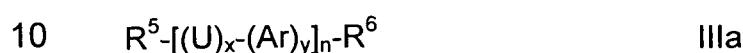
as -C≡C- or -CY¹=CY²-, or a single bond.

Typical groups Sp' are, for example, -(CH₂)_p-, -(CH₂CH₂O)_q-CH₂CH₂-, -CH₂CH₂-S-CH₂CH₂- or -CH₂CH₂-NH-CH₂CH₂- or -(SiR⁰R⁰⁰-O)_p-, with p being an integer from 2 to 12, q being an integer from 1 to 3 and R⁰ and R⁰⁰ having the meanings given above.

35

Preferred groups Sp' are ethylene, propylene, butylene, pentylene, hexylene, heptylene, octylene, nonylene, decylene, undecylene, dodecylene, octadecylene, ethyleneoxyethylene, methyleneoxybutylene, ethylene-thioethylene, ethylene-N-methyl-iminoethylene, 1-
 5 methylalkylene, ethenylene, propenylene and butenylene for example.

The polymers containing units of formula I, especially those of formula III, are preferably selected of formula IIIa



wherein U, Ar, n, x and y have the meanings of formula III, and

R⁵ and R⁶ have independently of each other one of the meanings of R¹,
 15 preferably halogen, or denote H, -CH₂Cl, -CHO, -CH=CH₂, -SiR'R''R''', -SnR'R''R''', -BR'R'', -B(OR')(OR''), -B(OH)₂, or P-Sp, wherein P and Sp are as defined in formula I, and R', R'' and R''' have independently of each other one of the meanings of R⁰ given in formula I, and two of R', R'' and R''' may also form a
 20 ring together with the hetero atom to which they are attached.

In the polymers according to the the present invention, the total number of repeating units n is preferably ≥ 5, very preferably ≥ 10, most preferably ≥ 50, and preferably up to 500, very preferably up to 1,000, most preferably
 25 up to 2,000, including any combination of the aforementioned lower and upper limits of n.

The polymers of the present invention include homopolymers and copolymers, like statistical or random copolymers, alternating copolymers
 30 and block copolymers, as well as combinations thereof.

Block copolymers may for example comprise or consist of one or more blocks formed by units of formula I and one or more blocks formed by units Ar, wherein Ar has one of the meanings as described above and
 35 below.

Another aspect of the invention relates to monomers of formula Ia



- 5 wherein U is a unit of formula I or selected from its preferred subformulae or preferred meanings as described above and below, and R^5 and R^6 have the meanings given in formula IIIa.

10 Especially preferred are monomers of formula Ia wherein R^5 and R^6 are, preferably independently of each other, selected from the group consisting of Cl, Br, I, O-tosylate, O-triflate, O-mesylate, O-nonaflate, $-\text{SiMe}_2\text{F}$, $-\text{SiMeF}_2$, $-\text{O-SO}_2\text{Z}^1$, $-\text{B}(\text{OZ}^2)_2$, $-\text{CZ}^3=\text{C}(\text{Z}^3)_2$, $-\text{C}\equiv\text{CH}$ and $-\text{Sn}(\text{Z}^4)_3$, wherein Z^{1-4} are selected from the group consisting of alkyl and aryl, each being optionally substituted, and two groups Z^2 may also form a cyclic group.

15 Preferably the repeating units of formula I, and the monomers of formula Ia and polymers of formula III and IIIa containing them, are selected from the following list of preferred embodiments, including any combination thereof:

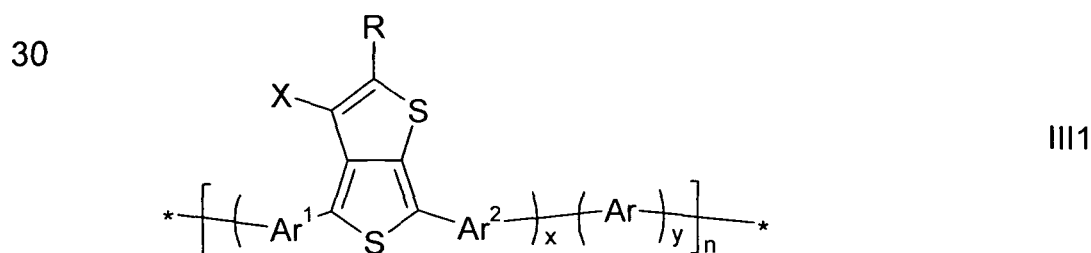
- 20
- in all repeating units x is 1 and y is 0, thereby forming a homopolymer of units U of the formula $-\text{[U]}_n-$,
 - in all repeating units x is 1 and y is 1, thereby forming an alternating copolymer of units U and Ar of the formula $-\text{[U-Ar]}_n-$,
- 25
- Ar^1 is of formula IIa and Ar^2 is of formula IIe,
 - Ar^1 is of formula IIb and Ar^2 is of formula IIg,
 - Ar^1 is of formula IIc and Ar^2 is of formula IIh,
 - Ar^1 is of formula IId and Ar^2 is of formula IIh,
- 30
- in formula IIb, IIc and IId, X^1 and X^2 are S,
 - in formula IIg, IIh and IIh, X^1 and X^2 are S,
 - in formula IIb, IIc and IId, X^1 and X^2 are Se,
 - in formula IIg, IIh and IIh, X^1 and X^2 are Se,
- 35
- in formula IIb, IIc and IId, one of X^1 and X^2 is S and the other is Se,

- in formula II_f, II_g and II_h, one of X¹ and X² is S, and the other is Se,
- in formula II_a and II_e W is S,
- in formula II_a and II_e W is Se,
- 5 - in formula II_a and II_e W is O,
- in formula II_a and II_e V is N,
- in formula II_a and II_e V is CH,
- X is H,
- 10 - X is F,
- Ar is selected from 1,4-phenylene, thiophene-2,5-diyl, selenophene-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl, thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, selenopheno[2,3-b]thiophene-2,5-diyl, benzo[1,2-b:4,5-b']dithiophene-2,6-diyl, 2,2-dithiophene, 2,2-diselenophene, dithieno[3,2-b:2',3'-d]silole-5,5-diyl, 4*H*-cyclopenta[2,1-b:3,4-b']dithiophene-2,6-diyl, carbazole-2,7-diyl, fluorene-2,7-diyl, indaceno[1,2-b:5,6-b']dithiophene-2,7-diyl, benzo[1'',2'':4,5;4'',5'':4',5']bis(silolo[3,2-b:3',2'-b']thiophene)-2,7-diyl, phenanthro[1,10,9,8-c,d,e,f,g]carbazole-2,7-diyl, benzo[2,1,3]thiadiazole-4,7-diyl, benzo[2,1,3]selenadiazole-4,7-diyl, benzo[2,1,3]oxadiazole-4,7-diyl, 2*H*-benzotriazole-4,7-diyl, 3,4-difluorothiophene-2,5-diyl, thieno[3,4-b]pyrazine-2,5-diyl, quinoxaline-5,8-diyl, thieno[3,4-b]thiophene-4,6-diyl, thieno[3,4-b]thiophene-6,4-diyl, 3,6-di-thien-2-yl-pyrrolo[3,4-c]pyrrole-1,4-dione, or [1,3]thiazolo[5,4-d][1,3]thiazole-2,5-diyl,
- 15 all of which are unsubstituted, or mono- or polysubstituted, preferably with R, R¹ or R^y as defined above and below,
- 20 - n is at least 5, preferably at least 10, very preferably at least 50, and up to 2,000, preferably up to 500.
- Mw is at least 5,000, preferably at least 8,000, very preferably at least 10,000, and preferably up to 300,000, very preferably up to 100,000,
- 25 - in formula II_b, II_c and II_d, one or more groups R⁴ are different from H,
- 30 - in formula II_f, II_g and II_h, one or more groups R⁴ are different from H,

- R is primary alkyl, alkoxy or thioalkyl with 1 to 30 C atoms, secondary alkyl, alkoxy or thioalkyl with 3 to 30 C atoms, or tertiary alkyl, alkoxy or thioalkyl with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,
- 5 - R is aryl, heteroaryl, aryloxy or heteroaryloxy, each of which is optionally alkylated or alkoxylated and has 4 to 30 ring atoms,
- R is $-\text{CO}-\text{R}^y$, $-\text{CO}-\text{O}-\text{R}^y$, or $-\text{O}-\text{CO}-\text{R}^y$, very preferably $-\text{CO}-\text{R}^y$ or $-\text{CO}-\text{O}-\text{R}^y$, wherein R^y is straight-chain, branched or cyclic alkyl with 1 to 30 C atoms, in which one or more non-adjacent C atoms are optionally replaced by $-\text{O}-$, $-\text{S}-$, $-\text{CO}-$, $-\text{CO}-\text{O}-$, $-\text{O}-\text{CO}-$, $-\text{O}-\text{CO}-\text{O}-$, $-\text{CR}^0=\text{CR}^{00}-$ or $-\text{C}\equiv\text{C}-$ and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN, or R^y is aryl, aryloxy, heteroaryl or heteroaryloxy having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R^1 as defined in formula I,
- 10 - R^y is primary alkyl with 1 to 30 C atoms, very preferably with 1 to 15 C atoms, secondary alkyl with 3 to 30 C atoms, or tertiary alkyl with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,
- 15 - R^y is $-(\text{CH}_2)_o-\text{CR}^a\text{R}^b\text{R}^c$, wherein o is 0, 1, 2, 3, 4 or 5, very preferably 0, 1 or 2, and R^a , R^b and R^c are independently of each other C_1 - C_{12} -alkyl, very preferably C_1 - C_8 -alkyl, which is optionally substituted by one or more F atoms, and wherein optionally one of R^a , R^b and R^c is H,
- 20 - R^y is aryl, heteroaryl, aryloxy or heteroaryloxy, each of which is optionally alkylated or alkoxylated and has 4 to 30 ring atoms,
- 25 - R^x is alkyl with 1 to 15 C atoms,
- R^0 and R^{00} are selected from H or C_1 - C_{10} -alkyl,
- 30 - R^1 is alkyl, alkoxy, alkylcarbonyl, alkylcarbonyloxy or alkoxycarbonyl with 1 to 30 C atoms, wherein one or more H atoms are optionally replaced by F,
- R^2 and R^3 have the same meaning,
- R^2 and R^3 are different from H,
- 35 - R^4 is H,

- R^2 , R^3 and R^4 , when being different from H, are selected from straight-chain alkyl, alkoxy and thioalkyl with 1 to 20 C atoms, wherein one or more H atoms are optionally replaced by F,
- 5 - R^2 , R^3 and R^4 , when being different from H, are selected from branched alkyl, alkoxy and thioalkyl with 3 to 20 C atoms, wherein one or more H atoms are optionally replaced by F, which is preferably secondary alkyl, alkoxy or thioalkyl with 3 to 20 C atoms, or tertiary alkyl, alkoxy or thioalkyl with 4 to 20 C atoms, wherein in all the aforementioned groups one or more H atoms are optionally replaced by F,
- 10 - R^2 , R^3 and R^4 , when being different from H, are selected from aryl, heteroaryl, aryloxy and heteroaryloxy, each of which is optionally alkylated or alkoxyated and has 4 to 30 ring atoms,
- R^5 and R^6 are selected from H, halogen, $-\text{CH}_2\text{Cl}$, $-\text{CHO}$, $-\text{CH}=\text{CH}_2$, $-\text{SiR}'\text{R}''\text{R}'''$, $-\text{SnR}'\text{R}''\text{R}'''$, $-\text{BR}'\text{R}''$, $-\text{B}(\text{OR}')(\text{OR}'')$, $-\text{B}(\text{OH})_2$, P-Sp, C_1 - C_{20} -alkyl, C_1 - C_{20} -alkoxy, C_2 - C_{20} -alkenyl, C_1 - C_{20} -fluoroalkyl and optionally substituted aryl or heteroaryl, wherein R' , R'' and R''' are as defined in formula IIa,
- 15 - R^5 and R^6 are, preferably independently of each other, selected from the group consisting of Cl, Br, I, O-tosylate, O-triflate, O-mesylate, O-nonaflate, $-\text{SiMe}_2\text{F}$, $-\text{SiMeF}_2$, $-\text{O}-\text{SO}_2\text{Z}^1$, $-\text{B}(\text{OZ}^2)_2$, $-\text{CZ}^3=\text{C}(\text{Z}^4)_2$, $-\text{C}\equiv\text{CH}$ and $-\text{Sn}(\text{Z}^4)_3$, wherein Z^{1-4} are selected from the group consisting of alkyl and aryl, each being optionally substituted, and two groups Z^2 may also form a cyclic group, very preferably from Br,
- 20 - one or more of R , R^1 , R^2 , R^3 , R^4 and R^y denotes or contains a group P-Sp-.

Preferred polymers of formula III are selected of formula III1



35

wherein R , X , R^2 , R^3 , Ar^1 , Ar^2 , Ar , x , y and n have the meanings given in

formula I and III or one of the preferred meanings given above and below.

Further preferred polymers of formula III are selected of formula III1a

5 R^5 -chain- R^6 III1a

wherein "chain" is a polymer chain of formula III1, and R⁵ and R⁶ have the meanings given in formula IIa or one of the preferred meanings given above and below.

10

The polymers of the present invention can be synthesized according to or in analogy to methods that are known to the skilled person and are described in the literature. Other methods of preparation can be taken from the examples. For example, they can be suitably prepared by aryl-aryl coupling reactions, such as Yamamoto coupling, Suzuki coupling, Stille coupling, Sonogashira coupling, Heck coupling or Buchwald coupling. Suzuki coupling and Yamamoto coupling are especially preferred.

15

20 The monomers which are polymerised to form the repeat units of the polymers can be prepared according to methods which are known to the person skilled in the art.

25 Preferably the polymers are prepared from monomers of formula Ia or its preferred embodiments as described above and below.

Another aspect of the invention is a process for preparing a polymer by coupling one or more identical or different monomeric units of formula I or monomers of formula Ia with each other and/or with one or more comonomers in a polymerisation reaction, preferably in an aryl-aryl coupling reaction.

30

Suitable and preferred comonomers are those of the formula

35 R^5-Ar-R^6

wherein Ar, R⁵ and R⁶ are as defined above.

Preferred methods for polymerisation are those leading to C-C-coupling or C-N-coupling, like Suzuki polymerisation, as described for example in WO 00/53656, Yamamoto polymerisation, as described in for example in T. Yamamoto et al., Progress in Polymer Science 1993, 17, 1153-1205 or in WO 2004/022626 A1, and Stille coupling. For example, when synthesizing a linear polymer by Yamamoto polymerisation, monomers as described above having two reactive halide groups is preferably used. When synthesizing a linear polymer by Suzuki polymerisation, preferably a monomer as described above is used wherein at least one reactive group is a boronic acid or boronic acid derivative group.

Suzuki polymerisation may be used to prepare homopolymers as well as statistical, alternating and block random copolymers. Statistical or block copolymers can be prepared for example from the above monomers of formula Ia wherein one of the reactive groups is halogen and the other reactive group is a boronic acid or boronic acid derivative group. The synthesis of statistical, alternating and block copolymers is described in detail for example in WO 03/048225 A2 or WO 2005/014688 A2.

Suzuki polymerisation employs a Pd(0) complex or a Pd(II) salt. Preferred Pd(0) complexes are those bearing at least one phosphine ligand such as Pd(Ph₃P)₄. Another preferred phosphine ligand is tris(*ortho*-tolyl)phosphine, i.e. Pd(*o*-Tol)₄. Preferred Pd(II) salts include palladium acetate, i.e. Pd(OAc)₂. Suzuki polymerisation is performed in the presence of a base, for example sodium carbonate, potassium phosphate or an organic base such as tetraethylammonium carbonate. Yamamoto polymerisation employs a Ni(0) complex, for example bis(1,5-cyclooctadienyl) nickel(0).

As alternatives to halogens as described above, leaving groups of formula -O-SO₂Z¹ can be used wherein Z¹ is as described above. Particular examples of such leaving groups are tosylate, mesylate and triflate.

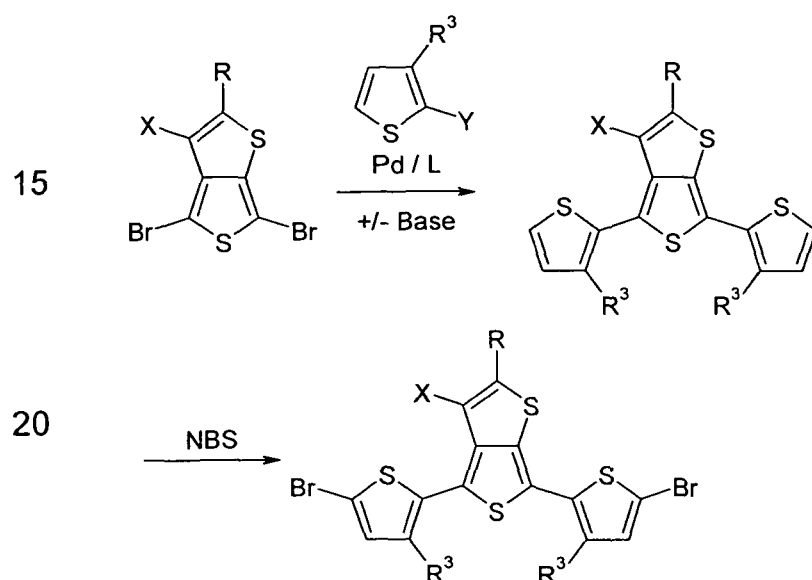
Especially suitable and preferred synthesis methods of the repeating

units, monomers and polymers of the present invention are illustrated in the synthesis schemes shown below.

Therein, R and R³ is preferably H, C_mH_{2m+1} (alkyl), COC_mH_{2m+1} (ketone) or COOC_mH_{2m+1} (ester), X is preferably H or F, m is preferably an integer from 1 to 20, Y is B(OR')₂, Sn(R')₃ or ZnBr, and Ar and R' are as defined in formula III and IIIa.

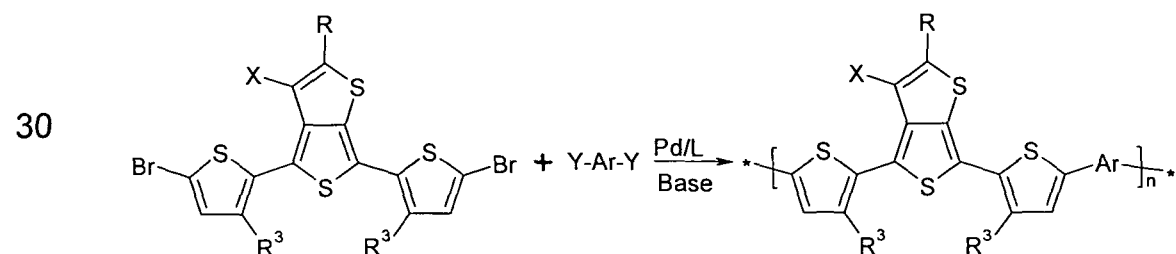
Scheme 1: Synthesis of 4,6-di-thiophen-2-yl-thieno[3,4-b]thiophene

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Scheme 2: Synthesis of alternating co-polymers of 4,6-di-thiophen-2-yl-thieno[3,4-b]thiophene



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Y = B(OR')₂ or Sn(R')₃

The novel methods of preparing monomers and polymers as described

above and below are another aspect of the invention.

The polymers according to the present invention can also be used in mixtures or polymer blends, for example together with monomeric
5 compounds or together with other polymers having charge-transport, semiconducting, electrically conducting, photoconducting and/or light emitting semiconducting properties, or for example with polymers having hole blocking or electron blocking properties for use as interlayers or charge blocking layers in OLED devices. Thus, another aspect of the
10 invention relates to a polymer blend comprising one or more polymers according to the present invention and one or more further polymers having one or more of the above-mentioned properties. These blends can be prepared by conventional methods that are described in prior art and known to the skilled person. Typically the polymers are mixed with each
15 other or dissolved in suitable solvents and the solutions combined.

Another aspect of the invention relates to a formulation comprising one or more polymers, mixtures or polymer blends as described above and below and one or more organic solvents.

20 Preferred solvents are aliphatic hydrocarbons, chlorinated hydrocarbons, aromatic hydrocarbons, ketones, ethers and mixtures thereof. Additional solvents which can be used include 1,2,4-trimethylbenzene, 1,2,3,4-tetramethyl benzene, pentylbenzene, mesitylene, cumene, cymene,
25 cyclohexylbenzene, diethylbenzene, tetralin, decalin, 2,6-lutidine, 2-fluoro-m-xylene, 3-fluoro-o-xylene, 2-chlorobenzotrifluoride, dimethylformamide, 2-chloro-6fluorotoluene, 2-fluoroanisole, anisole, 2,3-dimethylpyrazine, 4-fluoroanisole, 3-fluoroanisole, 3-trifluoro-methylanisole, 2-methylanisole, phenetol, 4-methylanisole, 3-methylanisole, 4-fluoro-3-methylanisole, 2-
30 fluorobenzonitrile, 4-fluoroveratrol, 2,6-dimethylanisole, 3-fluorobenzonitrile, 2,5-dimethylanisole, 2,4-dimethylanisole, benzonitrile, 3,5-dimethylanisole, N,N-dimethylaniline, ethyl benzoate, 1-fluoro-3,5-dimethoxybenzene, 1-methylnaphthalene, N-methylpyrrolidinone, 3-fluorobenzotrifluoride, benzotrifluoride, benzotrifluoride, diosane,
35 trifluoromethoxybenzene, 4-fluorobenzotrifluoride, 3-fluoropyridine, toluene, 2-fluorotoluene, 2-fluorobenzotrifluoride, 3-fluorotoluene, 4-

isopropylbiphenyl, phenyl ether, pyridine, 4-fluorotoluene, 2,5-difluorotoluene, 1-chloro-2,4-difluorobenzene, 2-fluoropyridine, 3-chlorofluorobenzene, 3-chlorofluorobenzene, 1-chloro-2,5-difluorobenzene, 4-chlorofluorobenzene, chlorobenzene, o-dichlorobenzene, 2-chlorofluorobenzene, p-xylene, m-xylene, o-xylene or mixture of o-, m-, and p-isomers. Solvents with relatively low polarity are generally preferred. For inkjet printing solvents with high boiling temperatures and solvent mixtures are preferred. For spin coating alkylated benzenes like xylene and toluene are preferred.

Examples of especially preferred solvents include, without limitation, dichloromethane, trichloromethane, monochlorobenzene, o-dichlorobenzene, tetrahydrofuran, anisole, morpholine, toluene, o-xylene, m-xylene, p-xylene, 1,4-dioxane, acetone, methylethylketone, 1,2-dichloroethane, 1,1,1-trichloroethane, 1,1,2,2-tetrachloroethane, ethyl acetate, n-butyl acetate, dimethylformamide, dimethylacetamide, dimethylsulfoxide, tetraline, decaline, indane, methyl benzoate, ethyl benzoate, mesitylene and/or mixtures thereof.

The concentration of the polymers in the solution is preferably 0.1 to 10% by weight, more preferably 0.5 to 5% by weight. Optionally, the solution also comprises one or more binders to adjust the rheological properties, as described for example in WO 2005/055248 A1.

After the appropriate mixing and ageing, solutions are evaluated as one of the following categories: complete solution, borderline solution or insoluble. The contour line is drawn to outline the solubility parameter-hydrogen bonding limits dividing solubility and insolubility. 'Complete' solvents falling within the solubility area can be chosen from literature values such as published in "Crowley, J.D., Teague, G.S. Jr and Lowe, J.W. Jr., Journal of Paint Technology, 38, No 496, 296 (1966)". Solvent blends may also be used and can be identified as described in "Solvents, W.H.Ellis, Federation of Societies for Coatings Technology, p9-10, 1986". Such a procedure may lead to a blend of 'non' solvents that will dissolve both the polymers of the present invention, although it is desirable to have at least one true solvent in a blend.

The polymers according to the present invention can also be used in patterned OSC layers in the devices as described above and below. For applications in modern microelectronics it is generally desirable to
5 generate small structures or patterns to reduce cost (more devices/unit area), and power consumption. Patterning of thin layers comprising a polymer according to the present invention can be carried out for example by photolithography, electron beam lithography or laser patterning.

10 For use as thin layers in electronic or electrooptical devices the polymers, polymer blends or formulations of the present invention may be deposited by any suitable method. Liquid coating of devices is more desirable than vacuum deposition techniques. Solution deposition methods are especially preferred. The formulations of the present invention enable the
15 use of a number of liquid coating techniques. Preferred deposition techniques include, without limitation, dip coating, spin coating, ink jet printing, letter-press printing, screen printing, doctor blade coating, roller printing, reverse-roller printing, offset lithography printing, flexographic printing, web printing, spray coating, brush coating or pad printing. Ink-jet
20 printing is particularly preferred as it allows high resolution layers and devices to be prepared.

Selected formulations of the present invention may be applied to prefabricated device substrates by ink jet printing or microdispensing.
25 Preferably industrial piezoelectric print heads such as but not limited to those supplied by Aprion, Hitachi-Koki, InkJet Technology, On Target Technology, Picojet, Spectra, Trident, Xaar may be used to apply the organic semiconductor layer to a substrate. Additionally semi-industrial heads such as those manufactured by Brother, Epson, Konica, Seiko
30 Instruments Toshiba TEC or single nozzle microdispensers such as those produced by Microdrop and Microfab may be used.

In order to be applied by ink jet printing or microdispensing, the polymers should be first dissolved in a suitable solvent. Solvents must fulfil the
35 requirements stated above and must not have any detrimental effect on the chosen print head. Additionally, solvents should have boiling points

>100°C, preferably >140°C and more preferably >150°C in order to prevent operability problems caused by the solution drying out inside the print head. Apart from the solvents methoned above, suitable solvents include substituted and non-substituted xylene derivatives, di-C₁₋₂-alkyl
5 formamide, substituted and non-substituted anisoles and other phenol-ether derivatives, substituted heterocycles such as substituted pyridines, pyrazines, pyrimidines, pyrrolidinones, substituted and non-substituted *N,N*-di-C₁₋₂-alkylanilines and other fluorinated or chlorinated aromatics.

10 A preferred solvent for depositing a polymer according to the present invention by ink jet printing comprises a benzene derivative which has a benzene ring substituted by one or more substituents wherein the total number of carbon atoms among the one or more substituents is at least three. For example, the benzene derivative may be substituted with a
15 propyl group or three methyl groups, in either case there being at least three carbon atoms in total. Such a solvent enables an ink jet fluid to be formed comprising the solvent with the polymer, which reduces or prevents clogging of the jets and separation of the components during spraying. The solvent(s) may include those selected from the following list
20 of examples: dodecylbenzene, 1-methyl-4-tert-butylbenzene, terpineol limonene, isodurene, terpinolene, cymene, diethylbenzene. The solvent may be a solvent mixture, that is a combination of two or more solvents, each solvent preferably having a boiling point >100°C, more preferably >140°C. Such solvent(s) also enhance film formation in the layer
25 deposited and reduce defects in the layer.

The ink jet fluid (that is mixture of solvent, binder and semiconducting compound) preferably has a viscosity at 20°C of 1-100 mPa·s, more preferably 1-50 mPa·s and most preferably 1-30 mPa·s.

30 The polymers or formulations according to the present invention can additionally comprise one or more further components or additives selected for for example from surface-active compounds, lubricating agents, wetting agents, dispersing agents, hydrophobing agents, adhesive agents, flow
35 improvers, defoaming agents, deaerators, diluents which may be reactive or

non-reactive, auxiliaries, colourants, dyes or pigments, sensitizers, stabilizers, nanoparticles or inhibitors.

5 The polymers according to the present invention are useful as charge transport, semiconducting, electrically conducting, photoconducting or light emitting materials in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices. In these devices, the polymers of the present invention are typically applied as thin layers or films.

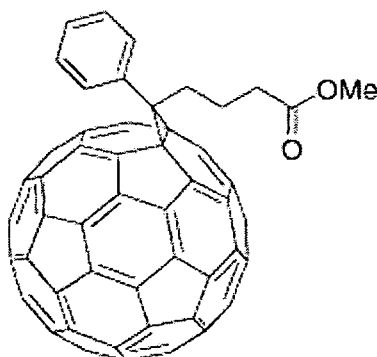
10 Thus, the present invention also provides the use of the semiconducting polymer, polymer blend, formulation or layer in an electronic device. The formulation may be used as a high mobility semiconducting material in various devices and apparatus. The formulation may be used, for example, in the form of a semiconducting layer or film. Accordingly, in another
15 aspect, the present invention provides a semiconducting layer for use in an electronic device, the layer comprising a polymer, polymer blend or formulation according to the invention. The layer or film may be less than about 30 microns. For various electronic device applications, the thickness may be less than about 1 micron thick. The layer may be deposited, for
20 example on a part of an electronic device, by any of the aforementioned solution coating or printing techniques.

The invention additionally provides an electronic device comprising a polymer, polymer blend, formulation or organic semiconducting layer
25 according to the present invention. Especially preferred devices are OFETs, TFTs, ICs, logic circuits, capacitors, RFID tags, OLEDs, OLETs, OPEDs, OPVs, solar cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, sensor devices, charge injection layers, Schottky
30 diodes, planarising layers, antistatic films, conducting substrates and conducting patterns.

Especially preferred electronic device are OFETs, OLEDs and OPV devices, in particular bulk heterojunction (BHJ) OPV devices. In an OFET,
35 for example, the active semiconductor channel between the drain and source may comprise the layer of the invention. As another example, in an

OLED device, the charge (hole or electron) injection or transport layer may comprise the layer of the invention.

For use in OPV devices the polymer according to the present invention is preferably used in a formulation that comprises or contains, more preferably consists essentially of, very preferably exclusively of, a p-type (electron donor) semiconductor and an n-type (electron acceptor) semiconductor. The p-type semiconductor is constituted by a polymer according to the present invention. The n-type semiconductor can be an inorganic material such as zinc oxide or cadmium selenide, or an organic material such as a fullerene derivate, for example (6,6)-phenyl-butyric acid methyl ester derivatized methano C₆₀ fullerene, also known as "PCBM" or "C₆₀PCBM", as disclosed for example in G. Yu, J. Gao, J.C. Hummelen, F. Wudl, A.J. Heeger, Science 1995, Vol. 270, p. 1789 ff and having the structure shown below, or an structural analogous compound with e.g. a C₇₀ fullerene group (C₇₀PCBM), or a polymer (see for example Coakley, K. M. and McGehee, M. D. *Chem. Mater.* 2004, 16, 4533).



C₆₀PCBM

A preferred material of this type is a blend or mixture of a polymer according to the present invention with a C₆₀ or C₇₀ fullerene or modified fullerene like PCBM. Preferably the ratio polymer:fullerene is from 2:1 to 1:2 by weight, more preferably from 1.2:1 to 1:1.2 by weight, most preferably 1:1 by weight. For the blended mixture, an optional annealing step may be necessary to optimize blend morphology and consequently OPV device performance.

The OPV device can for example be of any type known from the literature

[see e.g. Waldauf et al., Appl. Phys. Lett. **89**, 233517 (2006)].

A first preferred OPV device according to the invention comprises:

- 5 - a low work function electrode (11) (for example a metal, such as aluminum), and a high work function electrode (12) (for example ITO), one of which is transparent,
- 10 - a layer (13) (also referred to as "active layer") comprising a hole transporting material and an electron transporting material, preferably selected from OSC materials, situated between the electrodes (11,12); the active layer can exist for example as a bilayer or two distinct layers or blend or mixture of p-type and n-type semiconductor, forming a bulk heterjunction (BHJ) (see for example Coakley, K. M. and McGehee, M. D. *Chem. Mater.* **2004**, 16, 4533),
- 15 - an optional conducting polymer layer (14), for example comprising a blend of PEDOT:PSS (poly(3,4-ethylenedioxythiophene): poly(styrenesulfonate)), situated between the active layer (13) and the high work function electrode (12), to modify the work function of the high work function electrode to provide an ohmic contact for holes,
- 20 - an optional coating (15) (for example of LiF) on the side of the low workfunction electrode (11) facing the active layer (13), to provide an ohmic contact for electrons.

A second preferred OPV device according to the invention is an inverted OPV device and comprises:

- 25 - a low work function electrode (21) (for example a metal, such as gold), and a high work function electrode (22) (for example ITO), one of which is transparent,
- 30 - a layer (23) (also referred to as "active layer") comprising a hole transporting material and an electron transporting material, preferably selected from OSC materials, situated between the electrodes (21,22); the active layer can exist for example as a bilayer or two distinct layers or blend or mixture of p-type and n-type semiconductor, forming a BHJ,
- 35 - an optional conducting polymer layer (24), for example comprising a blend of PEDOT:PSS, situated between the active layer (23) and the low work function electrode (21) to provide an ohmic contact for electrons,

- an optional coating (25) (for example of TiO_x) on the side of the high workfunction electrode (22) facing the active layer (23), to provide an ohmic contact for holes.

5 In the OPV devices of the present invention the p-type and n-type semiconductor materials are preferably selected from the materials, like the polymer/fullerene systems, as described above. If the bilayer is a blend an optional annealing step may be necessary to optimize device performance.

10

The compound, formulation and layer of the present invention are also suitable for use in an OFET as the semiconducting channel. Accordingly, the invention also provides an OFET comprising a gate electrode, an insulating (or gate insulator) layer, a source electrode, a drain electrode and an organic semiconducting channel connecting the source and drain electrodes, wherein the organic semiconducting channel comprises a polymer, polymer blend, formulation or organic semiconducting layer according to the present invention. Other features of the OFET are well known to those skilled in the art.

20

OFETs where an OSC material is arranged as a thin film between a gate dielectric and a drain and a source electrode, are generally known, and are described for example in US 5,892,244, US 5,998,804, US 6,723,394 and in the references cited in the background section. Due to the advantages, like low cost production using the solubility properties of the compounds according to the invention and thus the processibility of large surfaces, preferred applications of these FETs are such as integrated circuitry, TFT displays and security applications.

30

The gate, source and drain electrodes and the insulating and semiconducting layer in the OFET device may be arranged in any sequence, provided that the source and drain electrode are separated from the gate electrode by the insulating layer, the gate electrode and the semiconductor layer both contact the insulating layer, and the source electrode and the drain electrode both contact the semiconducting layer.

35

An OFET device according to the present invention preferably comprises:

- a source electrode,
- a drain electrode,
- a gate electrode,
- 5 - a semiconducting layer,
- one or more gate insulator layers,
- optionally a substrate.

10 wherein the semiconductor layer preferably comprises a polymer, polymer blend or formulation as described above and below.

The OFET device can be a top gate device or a bottom gate device. Suitable structures and manufacturing methods of an OFET device are known to the skilled in the art and are described in the literature, for
15 example in US 2007/0102696 A1.

The gate insulator layer preferably comprises a fluoropolymer, like e.g. the commercially available Cytop 809M® or Cytop 107M® (from Asahi Glass). Preferably the gate insulator layer is deposited, e.g. by spin-coating,
20 doctor blading, wire bar coating, spray or dip coating or other known methods, from a formulation comprising an insulator material and one or more solvents with one or more fluoro atoms (fluorosolvents), preferably a perfluorosolvent. A suitable perfluorosolvent is e.g. FC75® (available from Acros, catalogue number 12380). Other suitable fluoropolymers and
25 fluorosolvents are known in prior art, like for example the perfluoropolymers Teflon AF® 1600 or 2400 (from DuPont) or Fluoropel® (from Cytonix) or the perfluorosolvent FC 43® (Acros, No. 12377). Especially preferred are organic dielectric materials having a low permittivity (or dielectric constant) from 1.0 to 5.0, very preferably from 1.8
30 to 4.0 ("low *k* materials"), as disclosed for example in US 2007/0102696 A1 or US 7,095,044.

In security applications, OFETs and other devices with semiconducting materials according to the present invention, like transistors or diodes, can
35 be used for RFID tags or security markings to authenticate and prevent counterfeiting of documents of value like banknotes, credit cards or ID

cards, national ID documents, licenses or any product with monetary value, like stamps, tickets, shares, cheques etc..

- 5 Alternatively, the materials according to the invention can be used in OLEDs, e.g. as the active display material in a flat panel display applications, or as backlight of a flat panel display like e.g. a liquid crystal display. Common OLEDs are realized using multilayer structures. An emission layer is generally sandwiched between one or more electron-transport and/ or hole-transport layers. By applying an electric voltage
- 10 electrons and holes as charge carriers move towards the emission layer where their recombination leads to the excitation and hence luminescence of the lumophor units contained in the emission layer. The inventive compounds, materials and films may be employed in one or more of the charge transport layers and/ or in the emission layer, corresponding to
- 15 their electrical and/ or optical properties. Furthermore their use within the emission layer is especially advantageous, if the compounds, materials and films according to the invention show electroluminescent properties themselves or comprise electroluminescent groups or compounds. The selection, characterization as well as the processing of suitable
- 20 monomeric, oligomeric and polymeric compounds or materials for the use in OLEDs is generally known by a person skilled in the art, see, e.g., Meerholz, Synthetic Materials, 111-112, 2000, 31-34, Alcala, J. Appl. Phys., 88, 2000, 7124-7128 and the literature cited therein.
- 25 According to another use, the materials according to this invention, especially those showing photoluminescent properties, may be employed as materials of light sources, e.g. in display devices, as described in EP 0 889 350 A1 or by C. Weder et al., Science, 279, 1998, 835-837.
- 30 A further aspect of the invention relates to both the oxidised and reduced form of the compounds according to this invention. Either loss or gain of electrons results in formation of a highly delocalised ionic form, which is of high conductivity. This can occur on exposure to common dopants. Suitable dopants and methods of doping are known to those skilled in the
- 35 art, e.g. from EP 0 528 662, US 5,198,153 or WO 96/21659.

The doping process typically implies treatment of the semiconductor material with an oxidating or reducing agent in a redox reaction to form delocalised ionic centres in the material, with the corresponding counterions derived from the applied dopants. Suitable doping methods
 5 comprise for example exposure to a doping vapor in the atmospheric pressure or at a reduced pressure, electrochemical doping in a solution containing a dopant, bringing a dopant into contact with the semiconductor material to be thermally diffused, and ion-implantation of the dopant into the semiconductor material.

10

When electrons are used as carriers, suitable dopants are for example halogens (e.g., I₂, Cl₂, Br₂, ICl, ICl₃, IBr and IF), Lewis acids (e.g., PF₅, AsF₅, SbF₅, BF₃, BCl₃, SbCl₅, BBr₃ and SO₃), protonic acids, organic acids, or amino acids (e.g., HF, HCl, HNO₃, H₂SO₄, HClO₄, FSO₃H and
 15 ClSO₃H), transition metal compounds (e.g., FeCl₃, FeOCl, Fe(ClO₄)₃, Fe(4-CH₃C₆H₄SO₃)₃, TiCl₄, ZrCl₄, HfCl₄, NbF₅, NbCl₅, TaCl₅, MoF₅, MoCl₅, WF₅, WCl₆, UF₆ and LnCl₃ (wherein Ln is a lanthanoid), anions (e.g., Cl⁻, Br⁻, I⁻, I₃⁻, HSO₄⁻, SO₄²⁻, NO₃⁻, ClO₄⁻, BF₄⁻, PF₆⁻, AsF₆⁻, SbF₆⁻, FeCl₄⁻, Fe(CN)₆³⁻, and anions of various sulfonic acids, such as aryl-SO₃⁻). When
 20 holes are used as carriers, examples of dopants are cations (e.g., H⁺, Li⁺, Na⁺, K⁺, Rb⁺ and Cs⁺), alkali metals (e.g., Li, Na, K, Rb, and Cs), alkaline-earth metals (e.g., Ca, Sr, and Ba), O₂, XeOF₄, (NO₂⁺) (SbF₆⁻), (NO₂⁺) (SbCl₆⁻), (NO₂⁺) (BF₄⁻), AgClO₄, H₂IrCl₆, La(NO₃)₃ · 6H₂O, FSO₂OOSO₂F, Eu, acetylcholine, R₄N⁺, (R is an alkyl group), R₄P⁺ (R is an alkyl group),
 25 R₆As⁺ (R is an alkyl group), and R₃S⁺ (R is an alkyl group).

The conducting form of the compounds of the present invention can be used as an organic "metal" in applications including, but not limited to, charge injection layers and ITO planarising layers in OLED applications,
 30 films for flat panel displays and touch screens, antistatic films, printed conductive substrates, patterns or tracts in electronic applications such as printed circuit boards and condensers.

The compounds and formulations according to the present invention may also be suitable for use in organic plasmon-emitting diodes (OPEDs), as
 35 described for example in Koller et al., Nature Photonics 2008 (published

online September 28, 2008).

According to another use, the materials according to the present invention can be used alone or together with other materials in or as alignment
5 layers in LCD or OLED devices, as described for example in US 2003/0021913. The use of charge transport compounds according to the present invention can increase the electrical conductivity of the alignment layer. When used in an LCD, this increased electrical conductivity can
10 reduce adverse residual dc effects in the switchable LCD cell and suppress image sticking or, for example in ferroelectric LCDs, reduce the residual charge produced by the switching of the spontaneous polarisation charge of the ferroelectric LCs. When used in an OLED device comprising a light emitting material provided onto the alignment layer, this increased
15 electrical conductivity can enhance the electroluminescence of the light emitting material. The compounds or materials according to the present invention having mesogenic or liquid crystalline properties can form oriented anisotropic films as described above, which are especially useful as alignment layers to induce or enhance alignment in a liquid crystal medium provided onto said anisotropic film. The materials according to
20 the present invention may also be combined with photoisomerisable compounds and/or chromophores for use in or as photoalignment layers, as described in US 2003/0021913.

According to another use the materials according to the present invention,
25 especially their water-soluble derivatives (for example with polar or ionic side groups) or ionically doped forms, can be employed as chemical sensors or materials for detecting and discriminating DNA sequences. Such uses are described for example in L. Chen, D. W. McBranch, H. Wang, R. Helgeson, F. Wudl and D. G. Whitten, Proc. Natl. Acad. Sci.
30 U.S.A. 1999, **96**, 12287; D. Wang, X. Gong, P. S. Heeger, F. Rininsland, G. C. Bazan and A. J. Heeger, Proc. Natl. Acad. Sci. U.S.A. 2002, **99**, 49; N. DiCesare, M. R. Pinot, K. S. Schanze and J. R. Lakowicz, Langmuir 2002, **18**, 7785; D. T. McQuade, A. E. Pullen, T. M. Swager, Chem. Rev. 2000, **100**, 2537.

35

Unless the context clearly indicates otherwise, as used herein plural forms

of the terms herein are to be construed as including the singular form and vice versa.

5 Throughout the description and claims of this specification, the words
"comprise" and "contain" and variations of the words, for example
"comprising" and "comprises", mean "including but not limited to", and are
not intended to (and do not) exclude other components.

10 It will be appreciated that variations to the foregoing embodiments of the
invention can be made while still falling within the scope of the invention.
Each feature disclosed in this specification, unless stated otherwise, may
be replaced by alternative features serving the same, equivalent or similar
purpose. Thus, unless stated otherwise, each feature disclosed is one
example only of a generic series of equivalent or similar features.

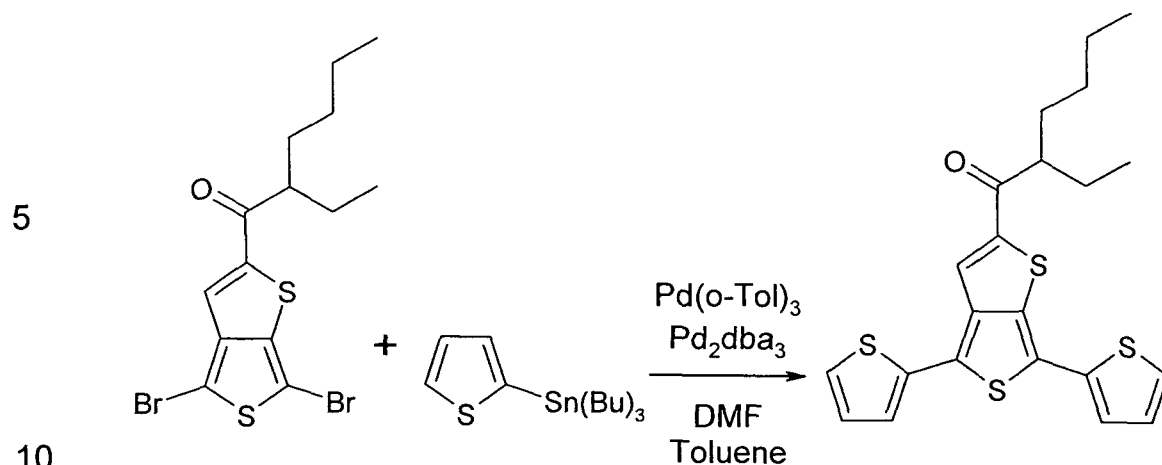
15 All of the features disclosed in this specification may be combined in any
combination, except combinations where at least some of such features
and/or steps are mutually exclusive. In particular, the preferred features of
the invention are applicable to all aspects of the invention and may be
20 used in any combination. Likewise, features described in non-essential
combinations may be used separately (not in combination).

It will be appreciated that many of the features described above,
particularly of the preferred embodiments, are inventive in their own right
25 and not just as part of an embodiment of the present invention.
Independent protection may be sought for these features in addition to or
alternative to any invention presently claimed.

30 The invention will now be described in more detail by reference to the
following examples, which are illustrative only and do not limit the scope of
the invention.

Example 1

35 1-(4,6-Di-thiophen-2-yl-thieno[3,4-b]thiophen-2-yl)-2-ethyl-hexan-1-one

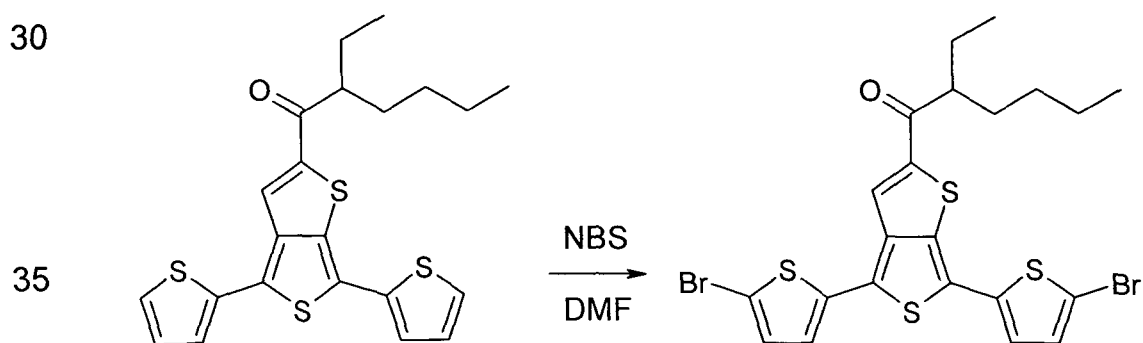


15 1-(4,6-Dibromo-thieno[3,4-b]thiophen-2-yl)-2-ethyl-hexan-1-one (6.500 g, 15.32 mmol), tributyl-thiophen-2-yl-stannane (10.70 cm³, 33.71 mmol), tri(o-tolyl)phosphine (0.373 g, 1.22 mmol), toluene (180 cm³) and dimethylformamide (20 cm³) were added to a 3-necked flask. The resulting mixture was carefully degassed for 30 minutes before adding

20 tris(dibenzylideneacetone)dipalladium(0) (0.140 g, 0.153 mmol). The mixture was then stirred at 110 °C for 16 hours before been cooling down to 23 °C and the solvents were removed *in vacuo*. Purification by column chromatography (eluent petroleum ether 40-60/dichloromethane/

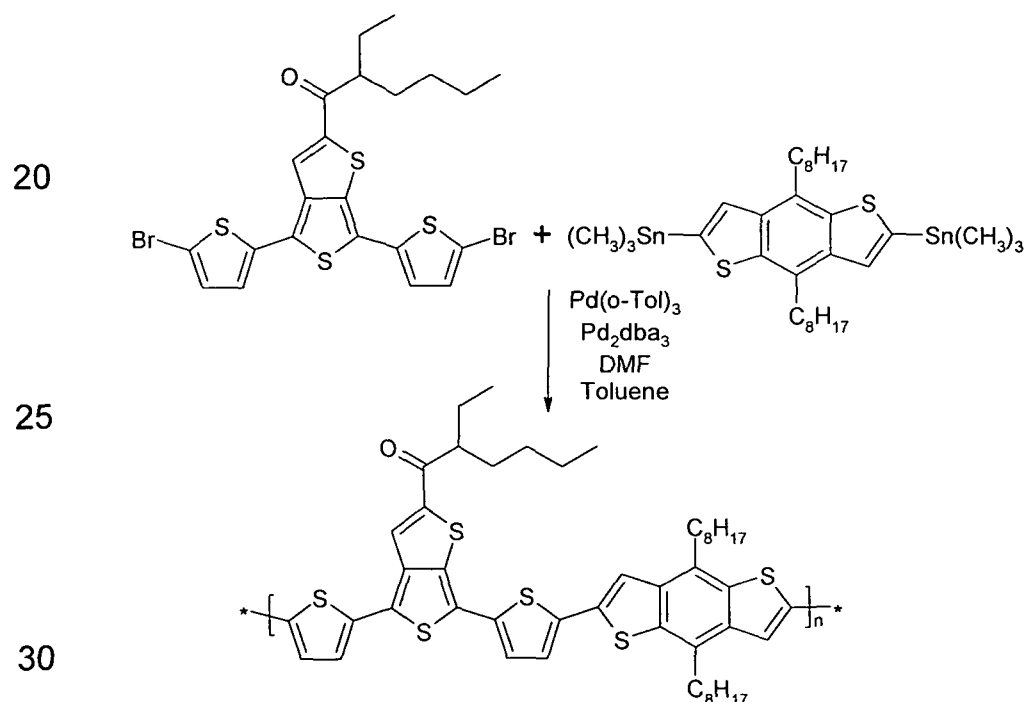
25 triethylamine in 50:50:1 ratio) yielded a red oily product, which recrystallised upon standing (4.99 g, yield: 76 %). NMR (¹H, 300 MHz, CDCl₃) : δ 7.86 (s, 1H); 7.38 (dd, *J*₁ = 4.6 Hz, *J*₂ = 1.2 Hz, 1H); 7.32 (m, 2H), 7.38 (dd, *J*₁ = 3.4 Hz, *J*₂ = 1.2 Hz, 1H); 7.12 (m, 2H); 3.21 (m, 1H); 1.81 (m, 2H); 1.59 (m, 3H); 1.30 (m, 3H); 0.90 (m, 6H)

1-[4,6-Bis-(5-bromo-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one



1-(4,6-Di-thiophen-2-yl-thieno[3,4-b]thiophen-2-yl)-2-ethyl-hexan-1-one (3.184 g, 7.393 mmol) was dissolved in DMF (35 cm³). Under the protection of light, NBS (2.500 g, 14.05 mmol) was added in one portion. The reactant was stirred for 20 minutes and then poured into 100 cm³ of 5% sodium thiosulfate solution with ice. The mixture was extracted into diethyl ether. Purification by column chromatography (eluent: petroleum ether 40-60/dichloromethane/triethylamine in 50:50:1 ratio) followed by recrystallization in a methanol / toluene mix. (3.470 g, yield : 80 %). NMR (¹H, 300 MHz, CDCl₃) : δ 7.74 (s, 1H); 7.08 (d, *J* = 4.0 Hz, 1H); 7.03 (m, 2H), 7.38 (d, *J* = 4.0 Hz, 1H); 3.21 (m, 1H); 1.81 (m, 2H); 1.59 (m, 3H); 1.30 (m, 3H); 0.90 (m, 6H)

Poly(2,6-[4,8-dioctyl-benzo{1,2-*b*;4,5-*b*}dithiophene]-alt-[1-{4,6-Bis-(5-thiophen-2-yl)-thieno[3,4-*b*]thiophen-2-yl}-2-ethyl-hexan-1-one])

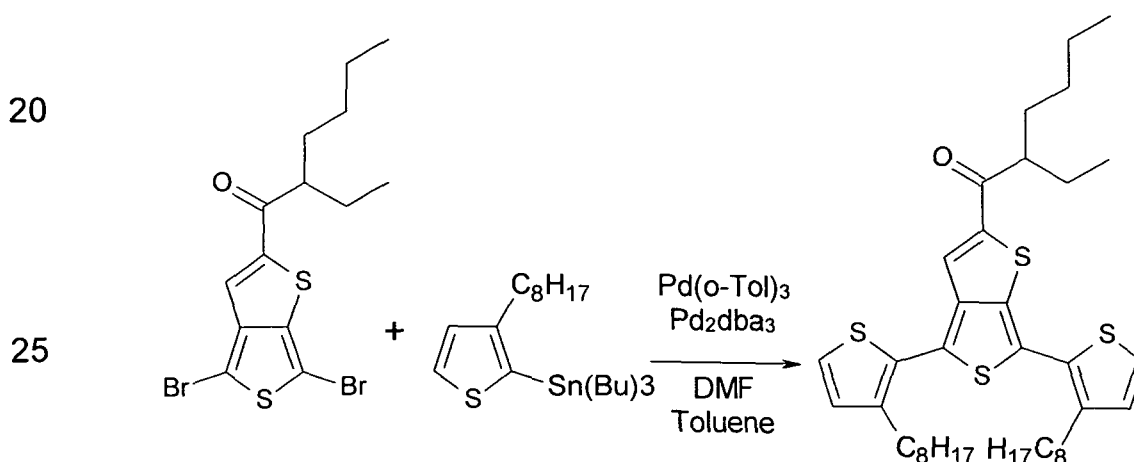


In a 50 cm³ round bottom flask, 1-[4,6-bis-(5-bromo-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one (294.2 mg, 0.500 mmol), 4,8-dioctyl-2,6-bis-trimethylstannanyl-benzo[1,2-*b*;4,5-*b*]dithiophene (370.2 mg, 0.500 mmol), tris(dibenzylideneacetone)dipalladium(0) (4.6

mg, 0.005 mmol) and tri(o-tolyl)phosphine (6.1 mg, 0.020 mmol) were dissolved in degassed toluene (12.0 cm³) and degassed dimethylformamide (3.0 cm³). The reaction mixture was further degassed and the reaction mixture heated at 100 °C for 120 minutes. The polymer was purified by precipitation into methanol:water (10:1), filtered and washed sequentially via Soxhlet extraction with acetone, petroleum ether (40 – 60 °C), chloroform and chlorobenzene. The chlorobenzene fraction was reduced to a smaller volume in vacuo and precipitated into methanol (200 cm³). The precipitated polymer was filtered and dried under vacuum at 25 °C overnight to afford the title product (35 mg, yield 8 %).
Mn = 2.9 kg.mol⁻¹, Mw = 5.3 kg.mol⁻¹.

Example 2

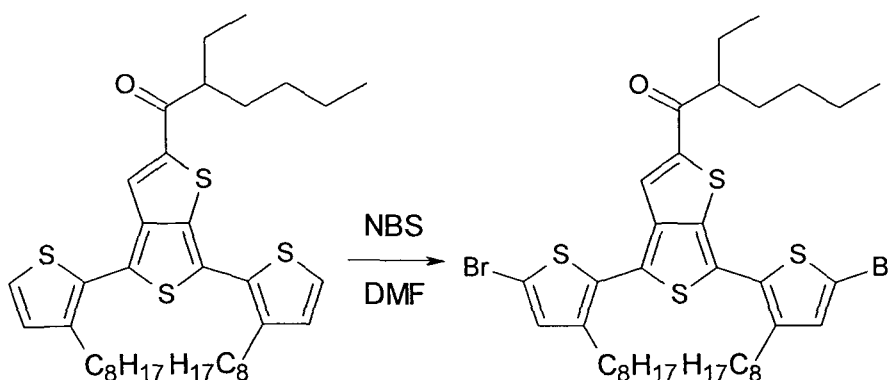
1-[4,6-Bis-(3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one



1-(4,6-Dibromo-thieno[3,4-b]thiophen-2-yl)-2-ethyl-hexan-1-one (6.150 g, 14.50 mmol) is weighted into a 500 cm³ 3-neck flask and then 2-tributyltin-3-octyl-thiophene (*Chem. Mater.* **2000**, 12, 1611–1621) (18.21 g, 31.89 mmol), tri-o-tolyl-phosphine (353mg, 1.16 mmol), N,N-dimethylformamide (18.0 cm³) and toluene (160 cm³) are added. The resulting mixture is carefully degassed for 10 minutes before adding tris(dibenzylideneacetone)dipalladium(0) (133 mg, 0.145 mmol). The

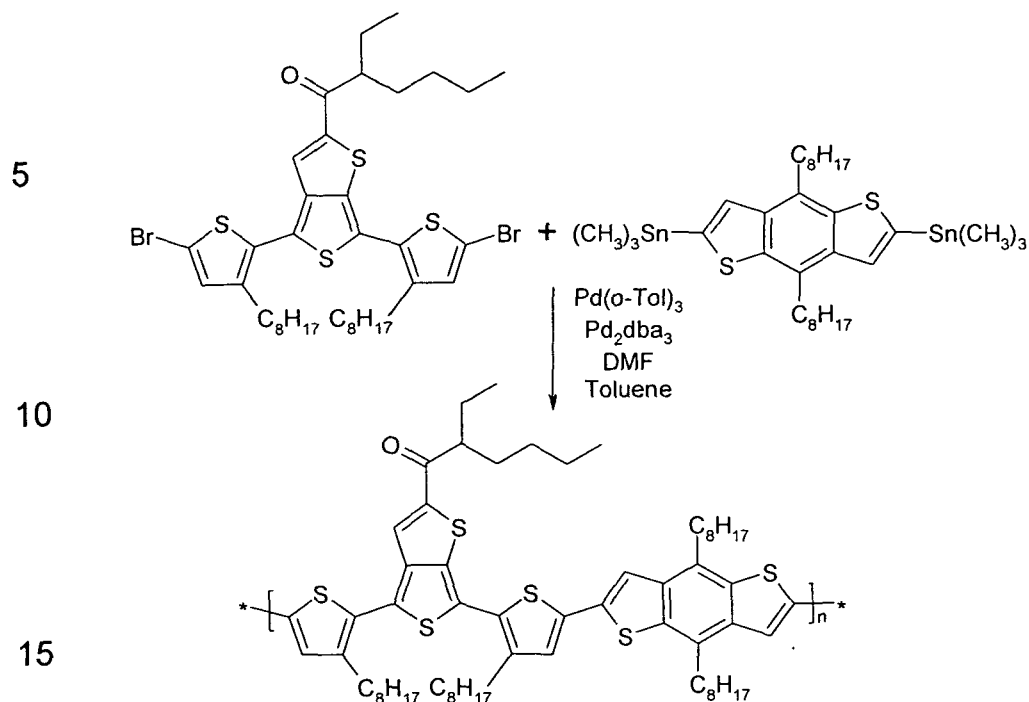
reaction mixture is heated at 110 °C for 16 hours under nitrogen protection before removing the solvent *in vacuo*. The crude product is purified by column chromatography (petroleum ether:dichloromethane, 70:30 to 60:40) to afford a red-orange oil (5.243 g, Yield: 57 %) NMR (¹H, 300 MHz, CDCl₃) : δ 7.76 (s, 1H); 7.36 (d, *J* = 5.2 Hz, 1H); 7.32 (d, *J* = 5.2 Hz, 1H); 7.06 (d, *J* = 5.3 Hz, 1H); 7.00 (d, *J* = 5.3 Hz, 1H); 3.17 (m, 1H); 2.81 (m, 4H); 1.67 (m, 8H); 1.24 (m, 24 H); 0.86 (m, 12H).

1-[4,6-Bis-(5-bromo-3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one



1-[4,6-Bis-(3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one (4.000 g, 6.106 mmol) is dissolved in anhydrous N,N-dimethylformamide (80 cm³). Under the protection of inert atmosphere, *N*-bromosuccinimide (2.065 g, 11.60 mmol) is added slowly in one portion. The reactant is stirred for 20 minutes and then poured into 100 cm³ of 5% sodium thiosulfate solution with ice. The mixture is extracted by diethyl ether, dried over sodium sulfate and vacuum down. The crude product is purified several times by column chromatography using petroleum ether:DCM (65:35) as eluent to afford a red solid (2.950 g, yield: 59 %). NMR (¹H, 300 MHz, CDCl₃): δ NMR (¹H, 300 MHz, CDCl₃) : δ 7.76 (s, 1H); 7.02 (s, 1H); 6.96 (s, 1H); 3.17 (m, 1H); 2.73 (m, 4H); 1.65 (m, 8H); 1.24 (m, 24 H); 0.85 (m, 12H).

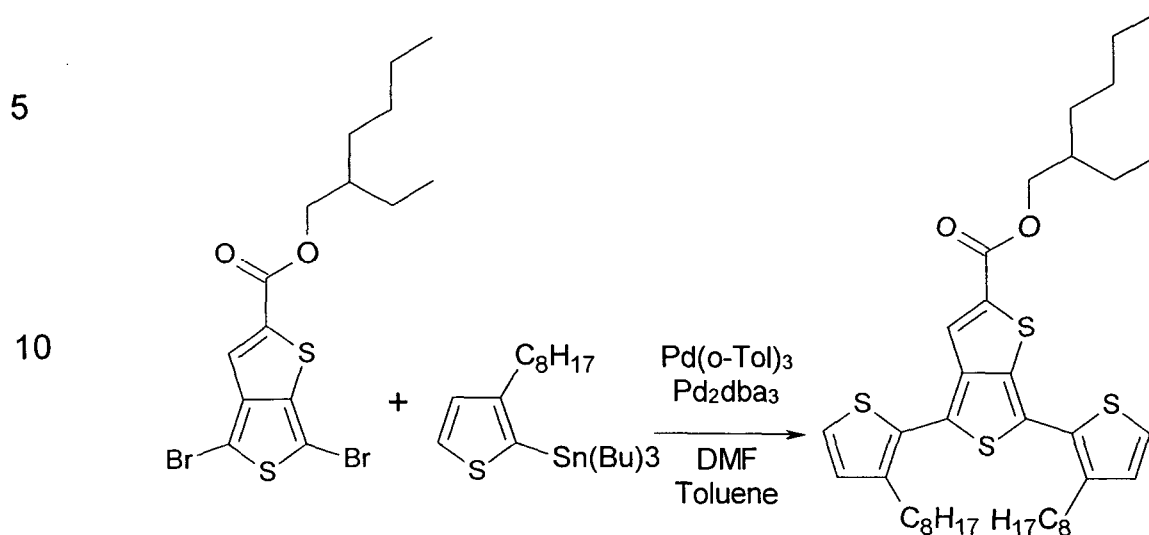
Poly(2,6-[4,8-dioctyl-benzo{1,2-*b*:4,5-*b'*}dithiophene]-alt-5,5'-[4,6-bis-(3-octyl-thiophen-2-yl)-2-(2-ethyl-hexan-1-one)-thieno[3,4-b]thiophene])



In a 50 cm³ round bottom flask, 1-[4,6-Bis-(5-bromo-3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophen-2-yl]-2-ethyl-hexan-1-one (516.6 mg, 0.6355 mmol), 4,8-dioctyl-2,6-bis-trimethylstannanyl-benzo[1,2-*b*;4,5-*b'*]dithiophene (470.5 mg, 0.6355 mmol), tris(dibenzylideneacetone)dipalladium(0) (2.9 mg, 3.2 μmol) and tri(*o*-tolyl)phosphine (7.7 mg, 25 μmol) are dissolved in degassed toluene (12.0 cm³) and degassed N,N-dimethylformamide (3.0 cm³). The reaction mixture is further degassed and the reaction mixture heated at 110 °C for 120 minutes. The polymer is purified by precipitation into methanol, filtered and washed sequentially via Soxhlet extraction with acetone, petroleum ether (40 – 60 °C) and chloroform. The chloroform fraction is reduced to a smaller volume *in vacuo* and precipitated into methanol (200 cm³). The precipitated polymer is filtered and dried under vacuum at 25 °C overnight to afford the title product (650 mg, yield 96 %). GPC (140 °C, 1,2,4-trichlorobenzene): M_n = 40.5 kg.mol⁻¹, M_w = 93.0 kg.mol⁻¹.

Example 3

4,6-Bis-(3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophene-2-carboxylic acid 2-

ethyl-hexyl ester

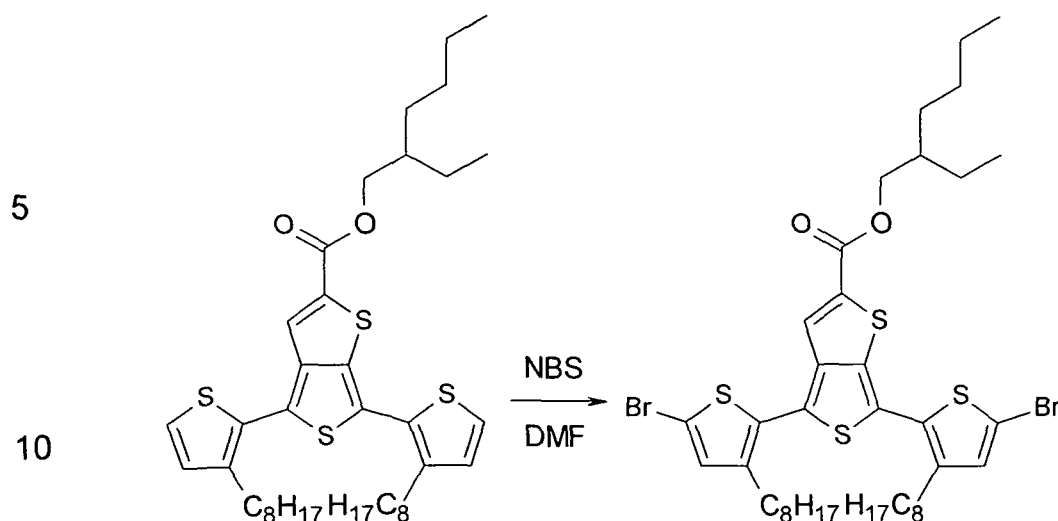
4,6-Dibromo-thieno[3,4-b]thiophene-2-carboxylic acid 2-ethyl-hexyl ester (4.000 g; 8.806 mmol) is weighted into a 250 cm³ 3-neck flask and then 2-tributyltin-3-octyl-thiophene (*Chem. Mater.* **2000**, 12, 1611–1621) (11.063 g; 19.373 mmol), tri-o-tolyl-phosphine (214 mg; 0.704 mmol), N,N-dimethylformamide (11.0 cm³) and toluene (95 cm³) are added. The resulting mixture is carefully degassed for 10 minutes before adding tris(dibenzylideneacetone)dipalladium(0) (80.637 mg; 0.088 mmol; 0.010 eq.). The reaction mixture is heated at 110 °C for 16 hours under nitrogen protection before removing the solvent *in vacuo*. The crude product is purified several times by column chromatography (petroleum ether:dichloromethane, 60:40) to afford a red-orange oil (1.350 g, Yield: 22 %). NMR (¹H, 300 MHz, CDCl₃) : δ 7.85 (s, 1H); 7.34 (d, *J* = 4.8 Hz, 1H); 7.32 (d, *J* = 4.9 Hz, 1H); 7.02 (d, *J* = 5.3 Hz, 1H); 7.00 (d, *J* = 5.3 Hz, 1H); 4.24 (d, *J* = 5.4 Hz, 2H); 2.80 (m, 4H); 1.67 (m, 5H); 1.24 (m, 28 H); 0.90 (m, 12H).

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4,6-Bis-(5-bromo-3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophene-2-carboxylic acid 2-ethyl-hexyl ester



15 4,6-Bis-(3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophene-2-carboxylic acid 2-ethyl-hexyl ester (1.350 g; 1.970 mmol; 1.000 eq.) is dissolved in anhydrous N,N-dimethylformamide (40 cm³). Under the protection of inert atmosphere, *N*-bromosuccinimide (0.666 g; 3.74 mmol; 1.90 eq.) is added slowly in one portion. The reactants are stirred for 20 minutes and then poured into 50 cm³ of 5% sodium thiosulfate solution with ice. The mixture is extracted by diethyl ether, dried over sodium sulfate and vacuum down.

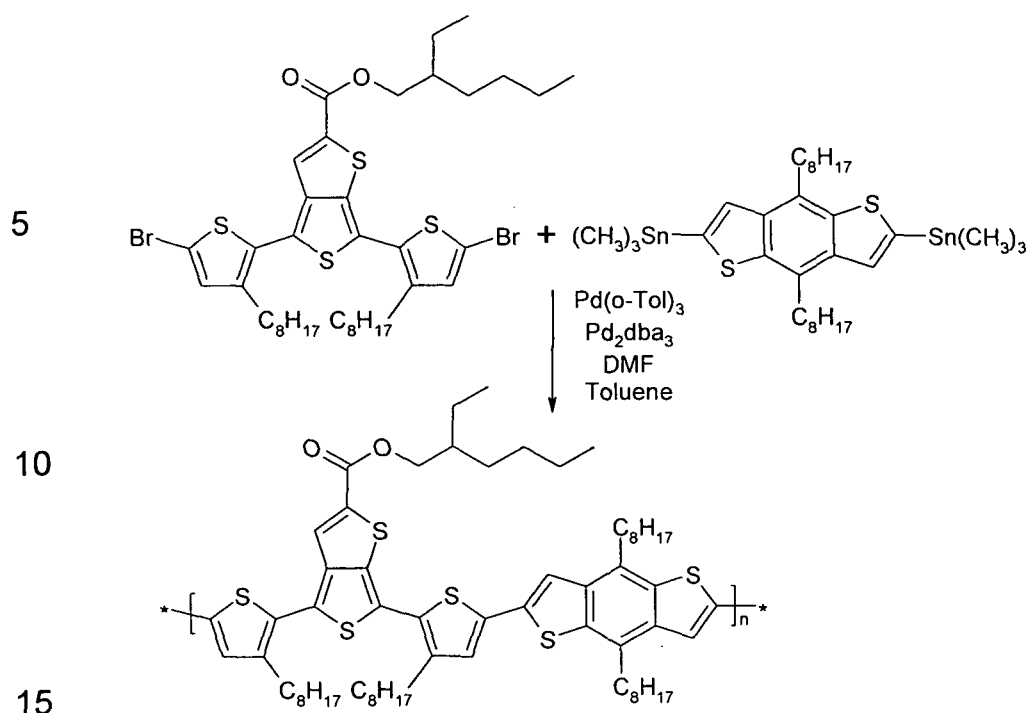
20 The crude product is purified by column chromatography using a mixture of petroleum ether and dichloromethane (80:20) as eluent to afford a red solid (1.243 g, yield: 75 %). NMR (¹H, 300 MHz, CDCl₃): δ NMR (¹H, 300 MHz, CDCl₃) : δ 7.77 (s, 1H); 6.99 (s, 1H); 6.96 (s, 1H); 4.24 (d, *J* =

25 5.8 Hz, 2H); 2.72 (m, 4H); 1.63 (m, 5H); 1.24 (m, 28 H); 0.86 (m, 12H).

Poly(2,6-[4,8-dioctyl-benzo{1,2-*b*;4,5-*b*}dithiophene]-alt-5,5'-[4,6-bis-(3-octyl-thiophen-2-yl)-thieno[3,4-*b*]thiophene-2-carboxylic acid 2-ethylhexyl ester])

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In a 50 cm³ round bottom flask, 4,6-bis-(5-bromo-3-octyl-thiophen-2-yl)-thieno[3,4-b]thiophene-2-carboxylic acid 2-ethyl-hexyl ester (421.5 mg, 0.5000 mmol), 4,8-dioctyl-2,6-bis-trimethylstannanyl-benzo[1,2-b;4,5-b']dithiophene (370.1 mg, 0.5000) mmol), tris(dibenzylideneacetone) dipalladium(0) (2.3 mg, 2.5 μmol) and tri(o-tolyl)phosphine (6.1 mg, 20 μmol) are dissolved in degassed toluene (12.0 cm³) and degassed N,N-dimethylformamide (3.0 cm³). The reaction mixture is further degassed and the reaction mixture heated at 110 °C for 120 minutes. The polymer is purified by precipitation into methanol, filtered and washed sequentially via Soxhlet extraction with acetone, petroleum ether (40 – 60 °C), chloroform and chlorobenzene. The chlorobenzene fraction is reduced to a smaller volume *in vacuo* and precipitated into methanol (200 cm³). The precipitated polymer is filtered and dried under vacuum at 25 °C overnight to afford the title product (325 mg, yield 59 %). GPC (140 °C, 1,2,4-trichlorobenzene): M_n = 43.6 kg.mol⁻¹, M_w = 91.6 kg.mol⁻¹.

Use Example A

35 Bulk heterojunction organic photovoltaic (BHJ OPV) device

5 BHJ_OPV devices are fabricated on ITO-glass substrates ($13\Omega/\square$), purchased from LUMTEC corporation. Substrates are cleaned using common solvents (acetone, IPA, DI water) in an ultrasonic bath prior to a conventional photolithography process is carried out to define the bottom electrodes (anodes).

10 A conducting polymer poly(ethylene dioxythiophene) doped with poly(styrene sulfonic acid) [Clevios VPAI 4083 (H.C. Starck)] is mixed on a 1:1 ratio with DI-water. This solution is sonicated for 20 minutes to ensure proper mixing and filtered using a $0.2\ \mu\text{m}$ filter and then is spin coated to a thickness of 20 nm. Substrates are exposed to ozone prior to the spin-coating process to ensure good wetting properties. Films are then annealed at $130\ ^\circ\text{C}$ for 30 minutes in an inert atmosphere where they are kept for the rest of the process.

15 As photoactive material a mixture of the polymer of Example 2 or 3, respectively, and the fullerene compound PCBM- C_{60} are used. Solutions of the photoactive material are prepared at the concentration and components ratio as shown in Table 1, and stirred overnight. Thin films of the solution are either spin coated or blade coated in an inert atmosphere to achieve thicknesses between 100 and 200 nm, measured using a
20 profilometer. A short drying period followed to ensure removal of excess of solvent. Typically, spin coated films are dried at $23\ ^\circ\text{C}$ for 10 minutes. Blade films are dried at $70\ ^\circ\text{C}$ for 3 minutes on the hotplate.

25 As the last step of the device fabrication, Calcium (30nm)/Al (200nm) cathodes are thermally evaporated through a shadow mask to define cells.

30 Samples are measured at $23\ ^\circ\text{C}$ using a Solar Simulator from Newport Ltd (model 91160) as light source and using a calibrated Si-cell as reference.

The device performances for the polymers of Example 2 and Example 3 are shown Table 1.

35

Table 1: Average open circuit potential (V_{oc}), current density (J_{sc}), fill

factor (FF), power conversion efficiency (PCE) and best power conversion efficiency for Example 2 and PCBM-C₆₀ ratio and Example 3 and PCBM-C₆₀ ratio.

5	Material	Ratio	Conc.	Voc	Jsc	FF	PCE	PCE SD	Best PCE
		Polymer: PCBM	mg·ml⁻¹	mV	mA·cm⁻²	%	%		%
	Ex. 2	1.0:1.5	30	605	-6.877	44.6	1.86	0.21	2.26
10	Ex. 2	1.0:2.0	30	500	-8.373	29.0	1.16	0.41	1.50
	Ex. 2	1.0:2.5	30	620	-4.436	42.1	1.15	0.24	1.54
	Ex. 3	1.0:1.5	30	557	-6.266	58.5	2.02	0.48	3.04
	Ex. 3	1.0:2.0	30	542	-8.233	46.6	2.08	0.25	2.55
15	Ex. 3	1.0:2.5	30	518	-6.207	46.0	1.45	0.48	2.06

Figure 1 shows typical J-V curves for a device containing a polymer of Example 2 (dashed line), and a device containing a polymer of Example 3 (continuous line), each having a ratio polymer:PCBM of 1.0:1.5.

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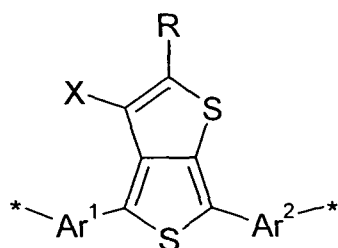
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Patent Claims

1. Conjugated polymer comprising one or more identical or different repeating units of formula I

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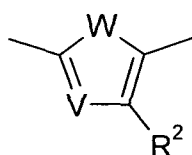


I

wherein the asterisks indicate a link to neighboured groups,

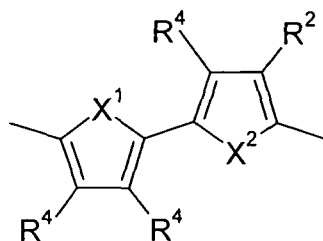
- Ar¹ is on each occurrence identically or differently a group selected from the following formulae

15



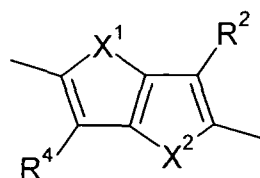
IIa

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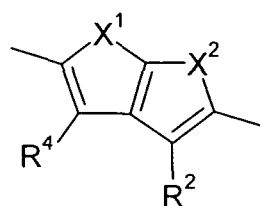
IIb

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IIc

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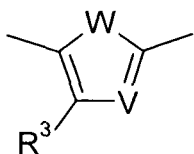


IIId

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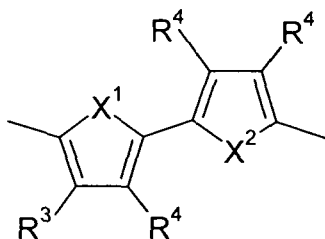
Ar^2 is on each occurrence identically or differently a group selected from the following formulae

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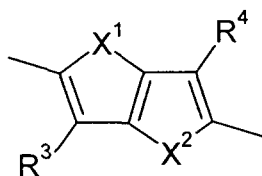
IIe

10



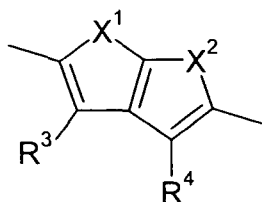
II f

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II g

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II h

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W is S, Se or O,

V is CH or N,

30

X^1 and X^2 are, on each occurrence identically or differently, and independently of each other, O, S or Se

X is H or F,

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R on each occurrence identically or differently, denotes F, Cl, Br, I, CN, or straight-chain, branched or cyclic alkyl

- with 1 to 35 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -CO-, -CO-O-, -O-CO-, -O-CO-O-, -CR⁰=CR⁰⁰- or -C≡C- and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN, or denotes aryl, heteroaryl, aryloxy, heteroaryloxy, arylcarbonyl, heteroarylcarbonyl, arylcarbonyloxy, heteroarylcarbonyloxy, aryloxycarbonyl or heteroaryloxycarbonyl having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R¹,
- R⁰ and R⁰⁰ are independently of each other H or optionally substituted carbyl or hydrocarbyl optionally comprising one or more hetero atoms,
- R¹ is on each occurrence identically or differently H, halogen, -CN, -NC, -NCO, -NCS, -OCN, -SCN, -C(=O)NR⁰R⁰⁰, -C(=O)X⁰, -C(=O)R⁰, -NH₂, -NR⁰R⁰⁰, -SH, -SR⁰, -SO₃H, -SO₂R⁰, -OH, -NO₂, -CF₃, -SF₅, optionally substituted silyl, carbyl or hydrocarbyl with 1 to 40 C atoms that is optionally substituted and optionally comprises one or more hetero atoms, or P-Sp-,
- R² and R³ on each occurrence identically or differently, and independently of each other, have one of the meanings given for R or R¹, which is preferably different from H,
- R⁴ has on each occurrence identically or differently one of the meanings given for R or R¹,
- P is a polymerisable or crosslinkable group,
- Sp is a spacer group or a single bond,
- X⁰ is halogen.

2. Polymer according to claim 1, which is selected of formula III



wherein

U is on each occurrence identically or differently a unit of formula I as defined in claim 1,

Ar is, on each occurrence identically or differently, an aryl or heteroaryl group that is optionally substituted,

Y^1 and Y^2 are independently of each other H, F, Cl or CN,

x is on each occurrence identically or differently 0, 1 or 2, wherein in at least one repeating unit, i.e. in at least one unit $-(U)_x-(Ar)_y-$, x is 1,

y is on each occurrence identically or differently 0, 1 or 2,

n is an integer > 1.

3. Polymer according to claim 1 or 2, which is selected of formula IIIa



wherein U, Ar, n, x and y have the meanings of claim 2, and

R^5 and R^6 have independently of each other one of the meanings of R^1 in claim 1, or denote H, $-CH_2Cl$, $-CHO$, $-CH=CH_2$, $-SiR'R''R'''$, $-SnR'R''R'''$, $-BR'R''$, $-B(OR')(OR'')$, $-B(OH)_2$, or P-Sp, wherein P and Sp are as defined above, and R' , R'' and R''' have independently of each other one of the meanings of R^0 in claim 1, and two of R' , R'' and R''' may also form a ring together with the hetero atom to

which they are attached.

4. Polymer according to claim 2 or 3, wherein x is 1 and y is 0 or 1,
- 5 5. Polymer according to one or more of claims 2 to 4, wherein Ar is selected from the group consisting of 1,4-phenylene, thiophene-2,5-diyl, selenophene-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl, thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, selenopheno[2,3-b]thiophene-2,5-diyl, benzo[1,2-b:4,5-b']dithiophene-2,6-diyl, 2,2-dithiophene, 2,2-diselenophene, dithieno[3,2-b:2',3'-d]silole-5,5-diyl, 4H-cyclopenta[2,1-b:3,4-b']dithiophene-2,6-diyl, carbazole-2,7-diyl, fluorene-2,7-diyl, indaceno[1,2-b:5,6-b']dithiophene-2,7-diyl, 15 benzo[1'',2'':4,5;4'',5'':4',5']bis(silolo[3,2-b:3',2'-b']thiophene)-2,7-diyl, phenanthro[1,10,9,8-c,d,e,f,g]carbazole-2,7-diyl, benzo[2,1,3]thiadiazole-4,7-diyl, benzo[2,1,3]selenadiazole-4,7-diyl, benzo[2,1,3]oxadiazole-4,7-diyl, 2H-benzotriazole-4,7-diyl, 3,4-difluorothiophene-2,5-diyl, thieno[3,4-b]pyrazine-2,5-diyl, quinoxaline-20 5,8-diyl, thieno[3,4-b]thiophene-4,6-diyl, thieno[3,4-b]thiophene-6,4-diyl, 3,6-di-thien-2-yl-pyrrolo[3,4-c]pyrrole-1,4-dione, or [1,3]thiazolo[5,4-d][1,3]thiazole-2,5-diyl, all of which are unsubstituted, or mono- or polysubstituted with R or R¹ as defined in claim 1.
- 25 6. Polymer according to one or more of claims 1 to 5, wherein R is -CO-R^y, -CO-O-R^y, or -O-CO-R^y, very preferably -CO-R^y or -CO-O-R^y, wherein R^y is straight-chain, branched or cyclic alkyl with 1 to 30 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -CO-, -CO-O-, -O-CO-, -O-CO-O-, -CR⁰=CR⁰⁰- or -C≡C- and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN, or R^y is aryl, aryloxy, heteroaryl or heteroaryloxy having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R¹ as defined in claim 1.
- 30
- 35

7. Polymer according to one or more of claims 1 to 6, wherein R^2 and R^3 , and R^4 when being different from H, are selected from straight-chain alkyl, alkoxy and thioalkyl with 1 to 20 C atoms, or are selected from branched alkyl, alkoxy and thioalkyl with 3 to 20 C atoms which is preferably secondary alkyl, alkoxy or thioalkyl with 3 to 20 C atoms or tertiary alkyl, alkoxy or thioalkyl with 4 to 20 C atoms, wherein in all the aforementioned groups one or more H atoms are optionally replaced by F, or are selected from aryloxy, heteroaryl or heteroaryloxy that is optionally alkylated or alkoxylated and has 4 to 30 ring atoms.
8. Mixture or blend comprising one or more polymers according to one or more of claims 1 to 7 and one or more compounds or polymers having semiconducting, charge transport, hole/electron transport, hole/electron blocking, electrically conducting, photoconducting or light emitting properties.
9. Formulation comprising one or more polymers, mixtures or blends according to one or more of claims 1 to 8, and one or more solvents, preferably selected from organic solvents.
10. Use of a polymer, mixture, blend or formulation according to one or more of claims 1 to 9 as charge transport, semiconducting, electrically conducting, photoconducting or light emitting material in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices.
11. Optical, electrooptical or electronic component or device comprising one or more polymers, mixtures, blends or formulations according to one or more of claims 1 to 10.
12. Component or device according to claim 11, which is selected from the group consisting of organic field effect transistors (OFET), thin film transistors (TFT), integrated circuits (IC), logic circuits, capacitors, radio frequency identification (RFID) tags, devices or components, organic light emitting diodes (OLED), organic light

emitting transistors (OLET), flat panel displays, backlights of displays, organic photovoltaic devices (OPV), solar cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, sensor devices, charge injection layers, charge transport layers or interlayers in polymer light emitting diodes (PLEDs), Schottky diodes, planarising layers, antistatic films, polymer electrolyte membranes (PEM), conducting substrates, conducting patterns, electrode materials in batteries, alignment layers, biosensors, biochips, security markings, security devices, and components or devices for detecting and discriminating DNA sequences.

13. Component or device according to claim 11 or 12, which is an OFET or a bulk heterojunction OPV device.

14. Monomer of formula Ia



wherein U is a unit of formula I as defined in claim 1, 6 or 7, and R^5 and R^6 have the meanings given in claim 3.

15. Process of preparing a polymer according to one or more of claims 1 to 7, by coupling one or more monomers according to claim 14 with each other, and/or with one or more monomers of the formula



wherein R^5 , R^6 and Ar are as defined claim 3 or 5, in an aryl-aryl coupling reaction.